

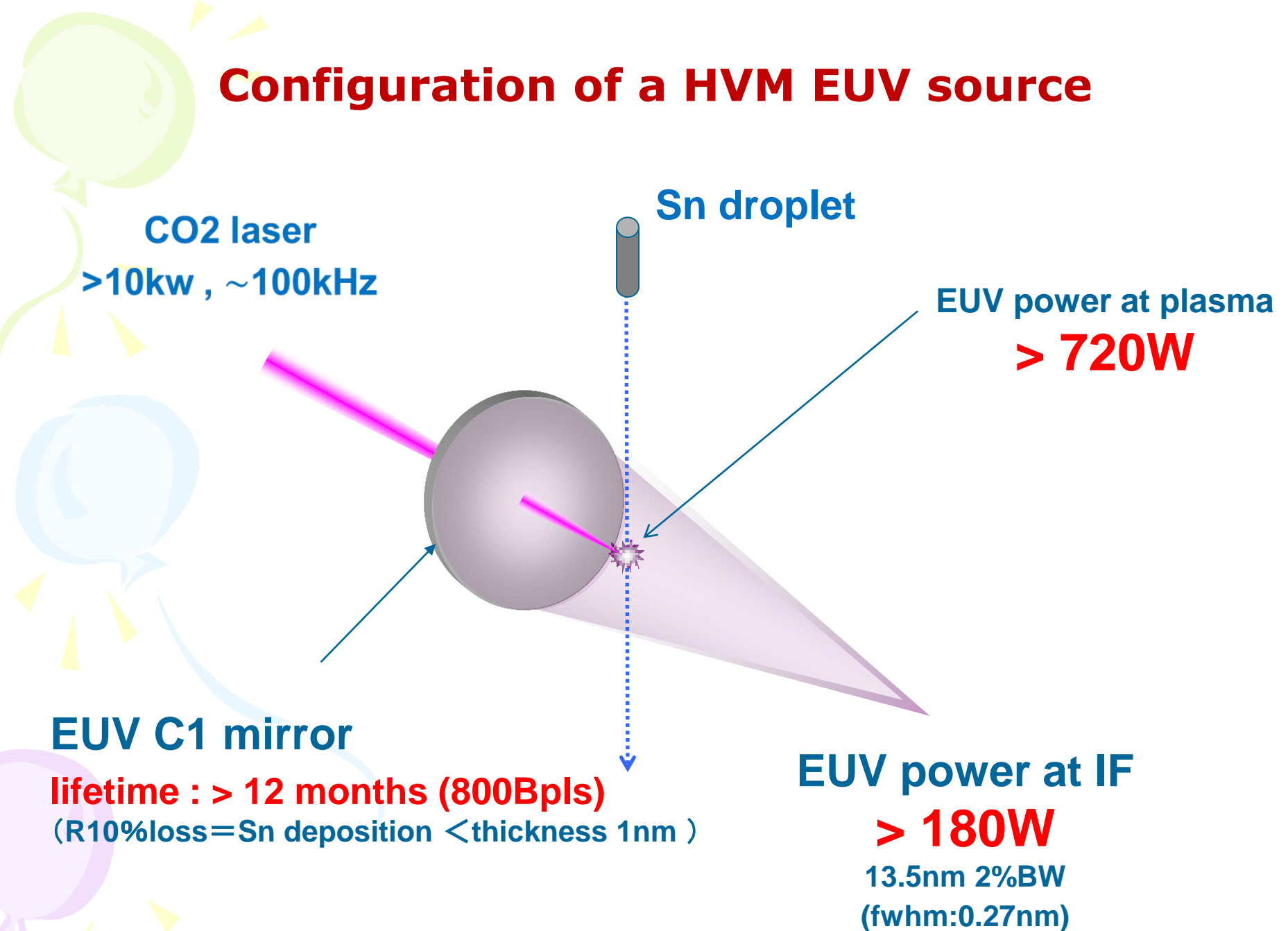
The background features abstract, flowing lines in shades of green, purple, and blue, interspersed with small yellow triangles, creating a dynamic and artistic feel.

# **Extendability of LPP EUV source technology in higher power (kW) / shorter wavelength (6.x nm) operation**

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**Waseda University(Tokyo)**  
**HiLase Project(Prague)**

**October 9, 2012 Dublin Ireland**

# Configuration of a HVM EUV source



# Scaling of the HVM source technology to kW range

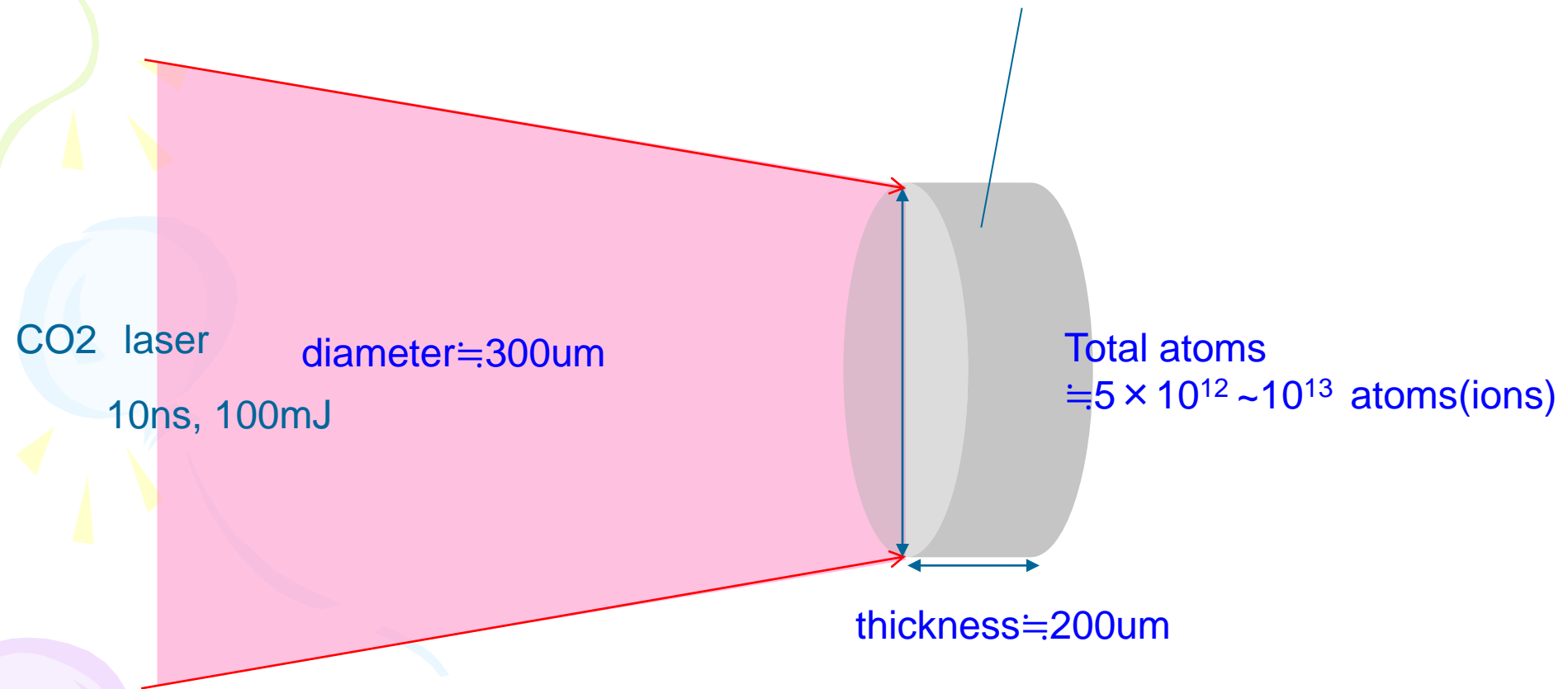
Source main parameters	Present HVM source*	Upgrade to kW range
EUV IF power	110W (13.5nm)	1kW (13.5nm)
CO <sub>2</sub> laser power	20kW	50kW
Conversion efficiency	2.5%	5%**
Collection efficiency	22%	40%

\*; Development of stable extreme-ultraviolet sources for use in lithography exposure systems, I.V.Fomenkov et.al. JM3 11(2), 021110 (April-Jun 2012)

\*\*; Gigaphoton press release, July 2012

# Ideal Sn target

Density  $\approx 10^{17} \sim 10^{18}$  atoms(ions)/cm<sup>3</sup>





# Operational parameters present HVM source

<b>Repetition rate</b>	<b>60kHz</b>
Droplet diameter	30μm
Irradiation mode	Double pulse
Droplet interval	1mm
Droplet speed	60m/s
Fuel recovery	Full atomization+ magnetic ion guide (H <sub>2</sub> cleaning)



# Operational parameters kW HVM source

<b>Repetition rate</b>	<b>150kHz</b>
Droplet diameter	10 $\mu$ m
Irradiation mode	Double pulse (picosecond prepulse)
Droplet interval	1mm
Droplet speed	150m/s
Fuel recovery	Full ionization+magnetic plasma guide (optical resonant ionization)

## Number of included atoms

<b>Droplet diameter (<math>\mu\text{m}</math>)</b>	<b>Sn</b>	<b>Gd</b>
<b>10</b>	<b><math>1.9 \times 10^{13}</math></b>	<b><math>1.4 \times 10^{13}</math></b>
<b>20</b>	<b><math>1.6 \times 10^{14}</math></b>	<b><math>1.1 \times 10^{14}</math></b>
<b>30</b>	<b><math>5.2 \times 10^{14}</math></b>	<b><math>3.6 \times 10^{14}</math></b>

Atomic weight: Sn 118.7    Gd 157.25

Specific gravity (g/cm<sup>3</sup>): Sn 7.3    Gd 7.4

# Optimization of pre-plasma conditioning

pre-pulse

expansion

CO<sub>2</sub> laser irradiation

→ Full ionization

Small droplet  
( $d=10\text{ }\mu\text{m}$ )

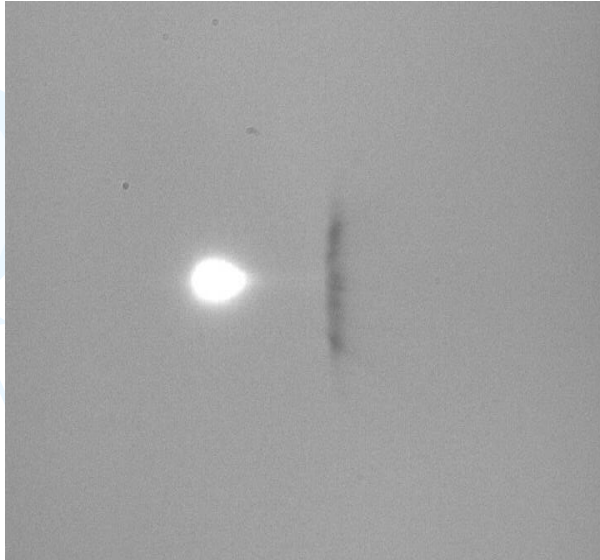
$D > 100\text{ }\mu\text{m}$

Magnetic ion guide

Optimize density, temperature and spatial distribution  
for main pulse heating to achieve high EUV conversion efficiency  
and **full exhaust of Sn atoms**



# Droplet with pre-pulse irradiation

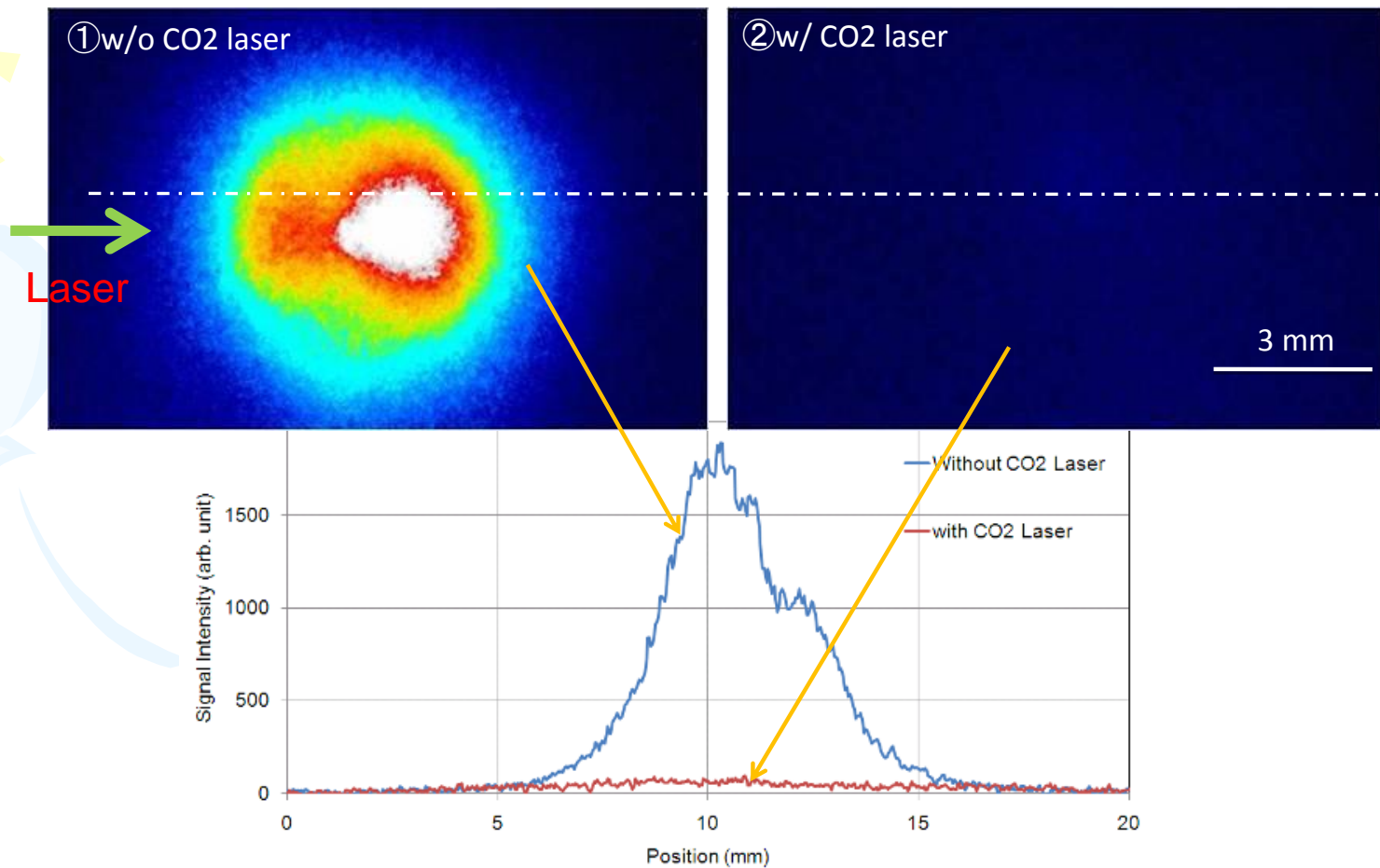


Without main pulse



With main pulse

# LIF measurements of neutrals in mist target



# Main pulse irradiation

## Plasma expansion is characterized by two phases

At  $t = 0$  the electron component of a finite plasma mass is heated to a uniform temperature  $T_e(r, 0) = T_{e0}$ .

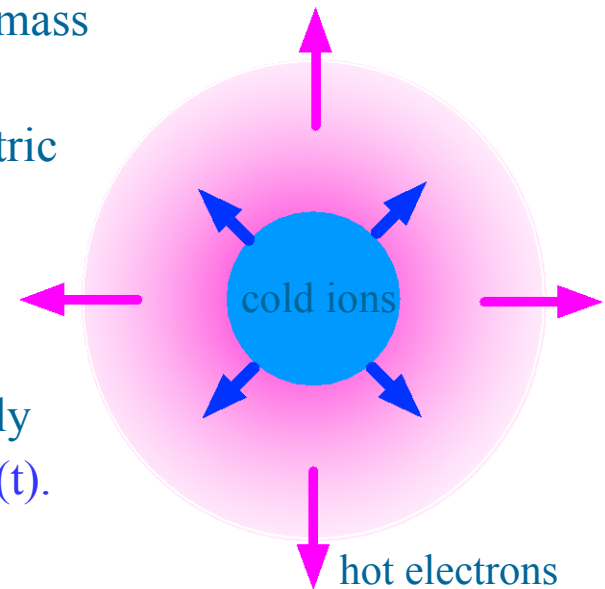
Hot electrons expand and create an ambipolar electric field  $E(r, t)$ , which drags the cold ions.

### Assumptions

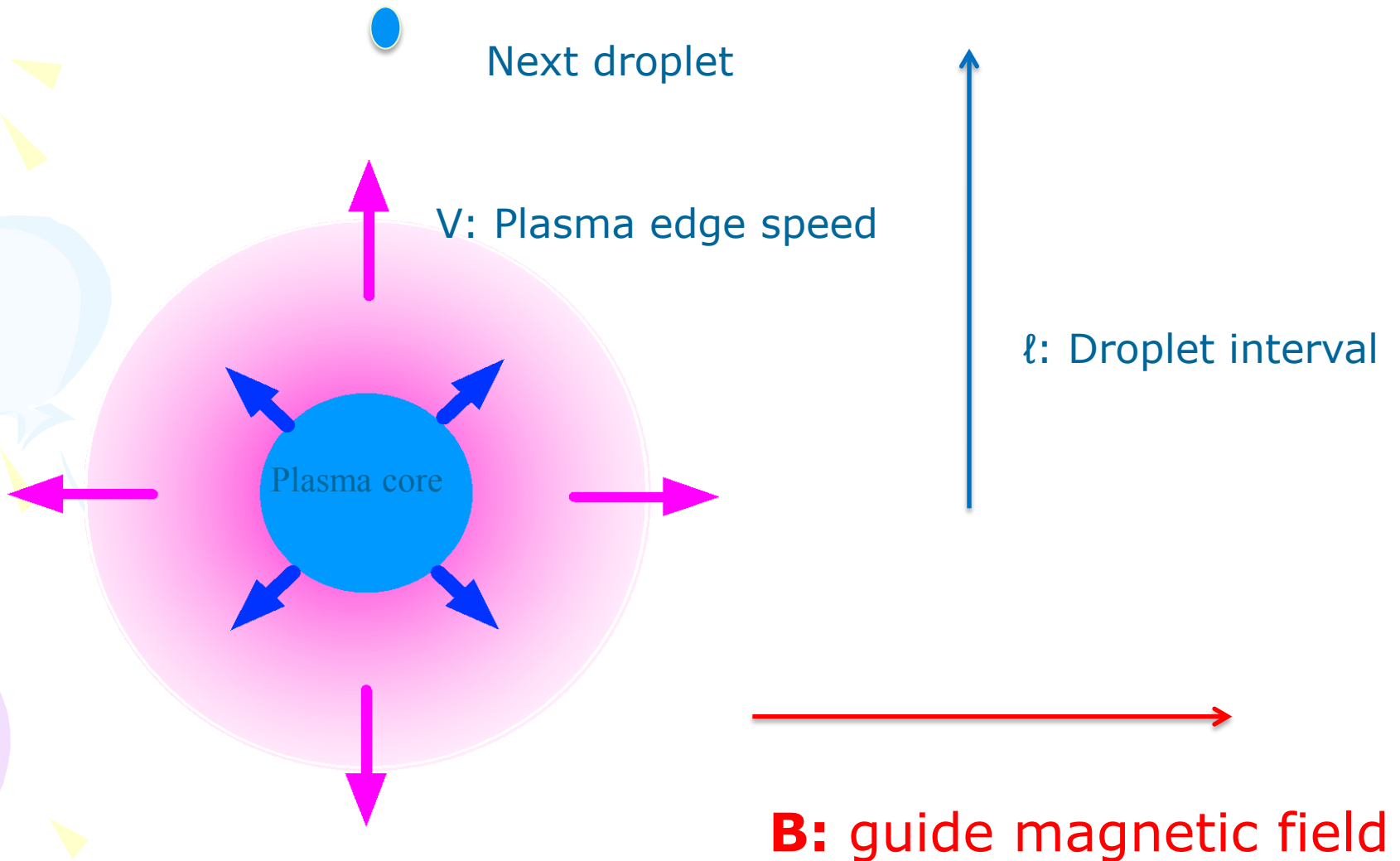
- There are no collisions between electrons and ions.
- At all times, the electron temperature is very quickly leveled off across the plasma volume:  $T_e(r, t) = T_e(t)$ .

**Isothermal phase** : during laser irradiation, Energy spectrum is established

**Adiabatic phase** : after laser irradiation, Energy spectrum is unchanged



# Expansion of plasma after main pulse



Three balloons (green, blue, and purple) are visible on the left side of the slide, each with yellow streamers and triangular flags.

# Expanding plasma interference to the next droplet

$\ell$  ( droplet interval)                      1mm  
 $V$  (plasma edge speed)                       $10^{**6}$  cm/s

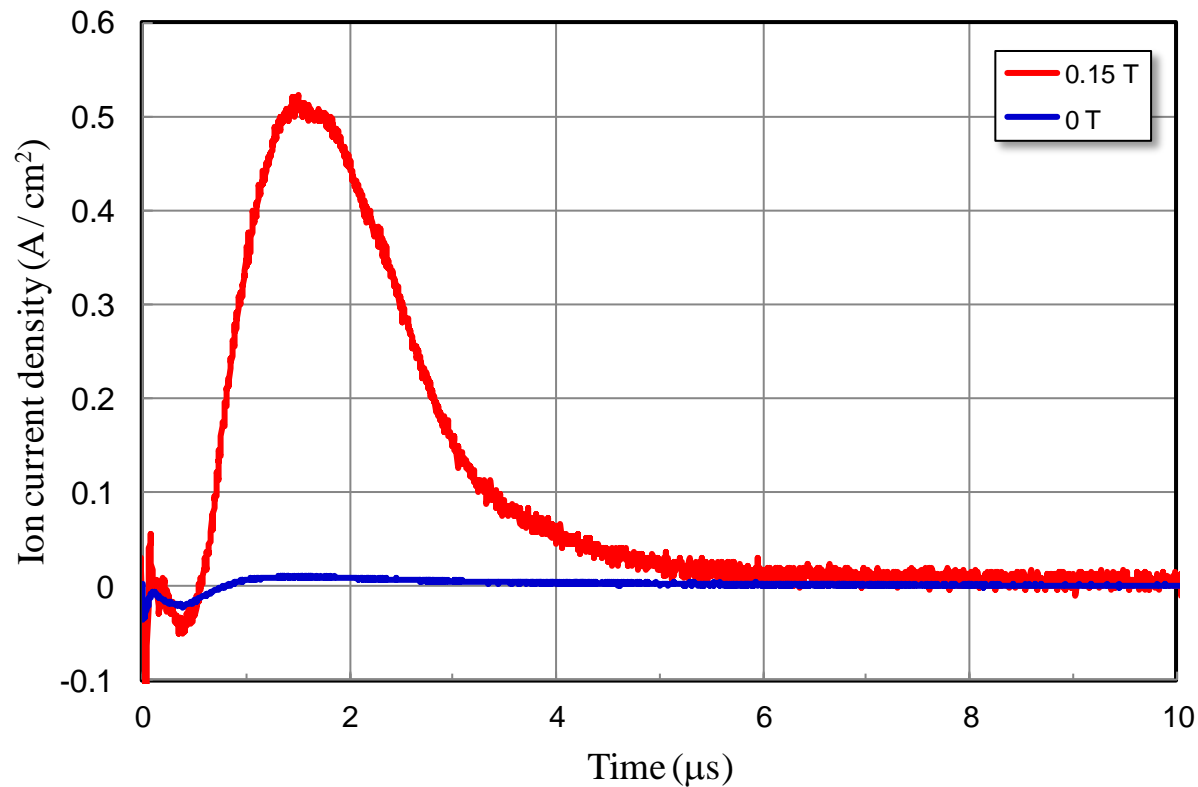
$t$  (plasma expansion time to the next droplet)  
;  $0.1\mu\text{S}$

**Density is  $10^{**-6}$  times lower from initial droplet**

# Measured ion flux at Faraday Cup

Ion beam duration  $< 2\mu\text{s}$

Ion density on magnetic axis





# Time parameters

Plasma exhaust  $2\mu\text{S}$

Droplet interval  $7\mu\text{S}$   
(1mm interval, 150kHz)

*Repetition rate increase to 150kHz is necessary  
for kW IF power realization*



# Component technologies improvement

- Droplet generator at 150kHz operation  
; 150m/s droplet final speed required
- Picosecond, ~mJ solid state laser as pre-pulse  
; thin disc laser
- CO<sub>2</sub> laser dual mode operation at 150kHz
- Gas free vacuum environment  
; laser resonant ionization of neutrals



# Fast droplet flow by higher back pressure

## § Droplet Technology

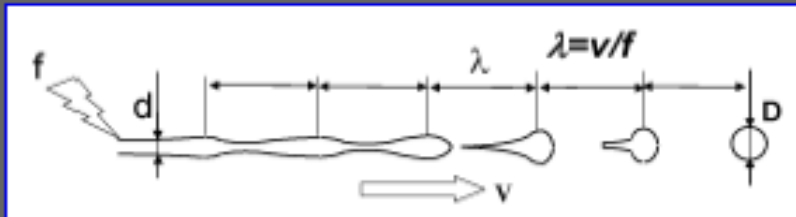
Continuous Jet Method [Rayleigh's Theory]  
- Uniform droplets generation from continuous jet

Surface Position :  $r$

$$r = (d/2) + \alpha e^{qt} \cos(2\pi x / \lambda)$$

$$q_{\max} = 0.97 \sqrt{(\sigma / \rho d^3)} \text{ @ } \lambda/d = 4.51$$

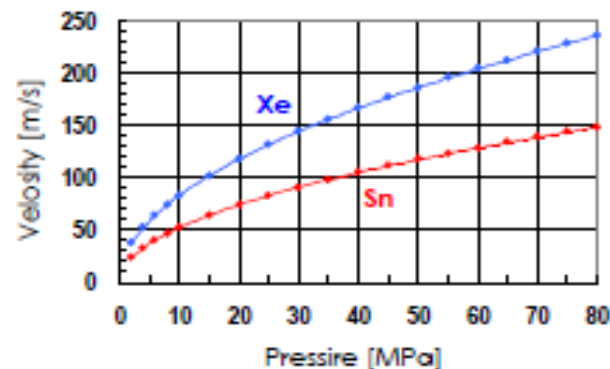
$d$  : Jet dia.  
 $\sigma$  : Surface Tension  
 $\alpha$  : Initial Disturbance  
 $q$  : Growth rate  
 $\rho$  : Density  
 $f$  : Frequency



Bernoulli's theorem

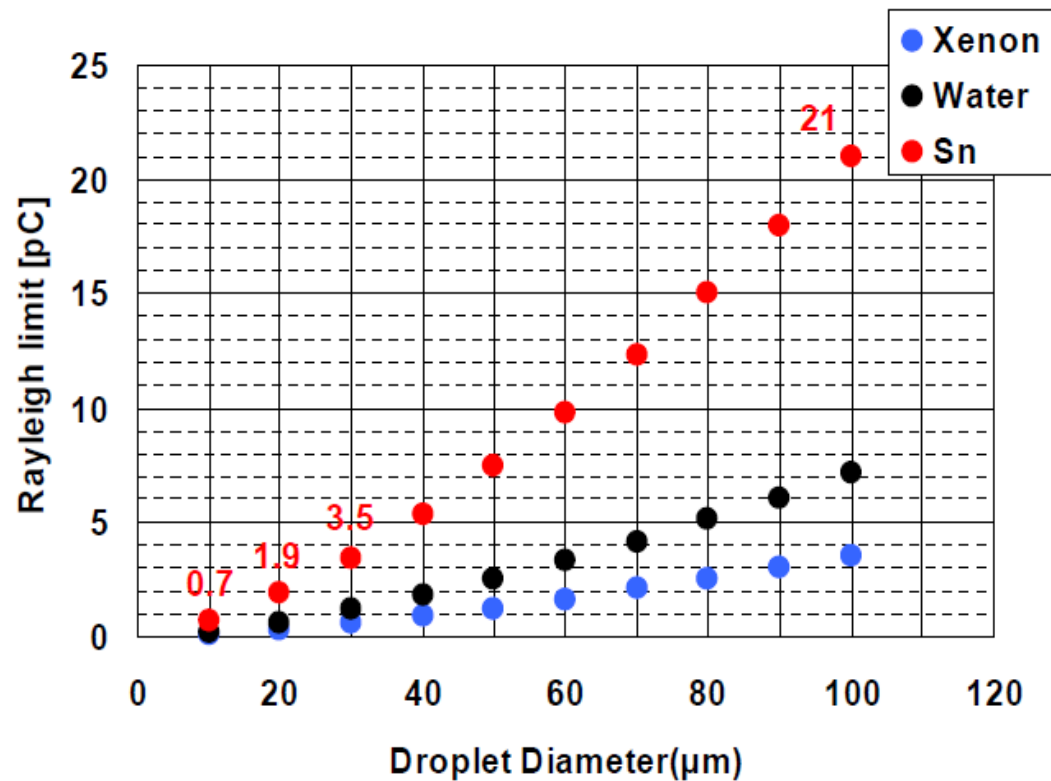
$$v = \sqrt{\frac{2\Delta P}{\rho}}$$

$v$  : Velocity  
 $\Delta P$  : Pressure  
 $\rho$  : Density



# Electrostatic acceleration

Rayleigh limit  
(maximum charge on droplet)



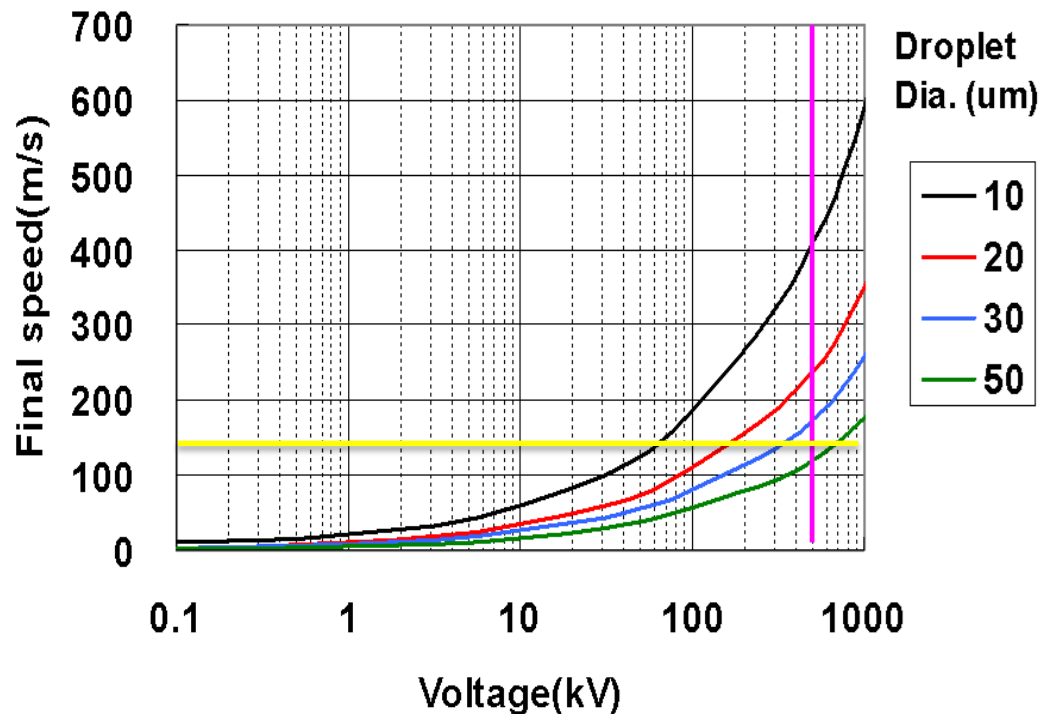
$$Q_{\max} = \sqrt{64\pi^2 \varepsilon_0 r^3 \sigma}$$

$\varepsilon_0$  : permittivity

$r$  : Droplet radius

$\sigma$  : Surface tension

# Droplet acceleration to 150m/s



$$v_{final} = \sqrt{\frac{2QV}{m} + v_0^2}$$

Q: Charge

V: Acceleration voltage

$\sigma$ : Surface tension

m: Mass

$v_0$ : Initial speed

**possible With 80kV static acceleration**



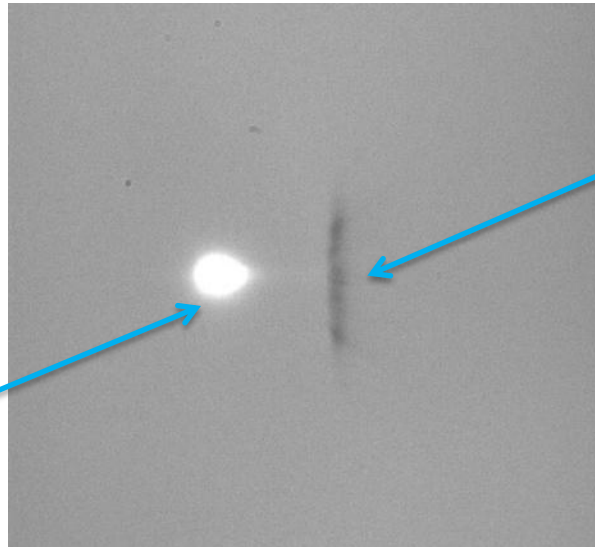
150m/s droplet speed



Static high voltage limit

# Mist target generation by picosecond ablation of Sn droplet

Pre-pulsed  
droplet



Mist target



## Pressure in transient phase ; atomic motion + intermolecular force

$$P = \rho k_B T + \frac{1}{3V} \left\langle \sum_{i=1}^N \sum_{j < i} \vec{F}_{ij} \cdot \vec{r}_{ij} \right\rangle$$

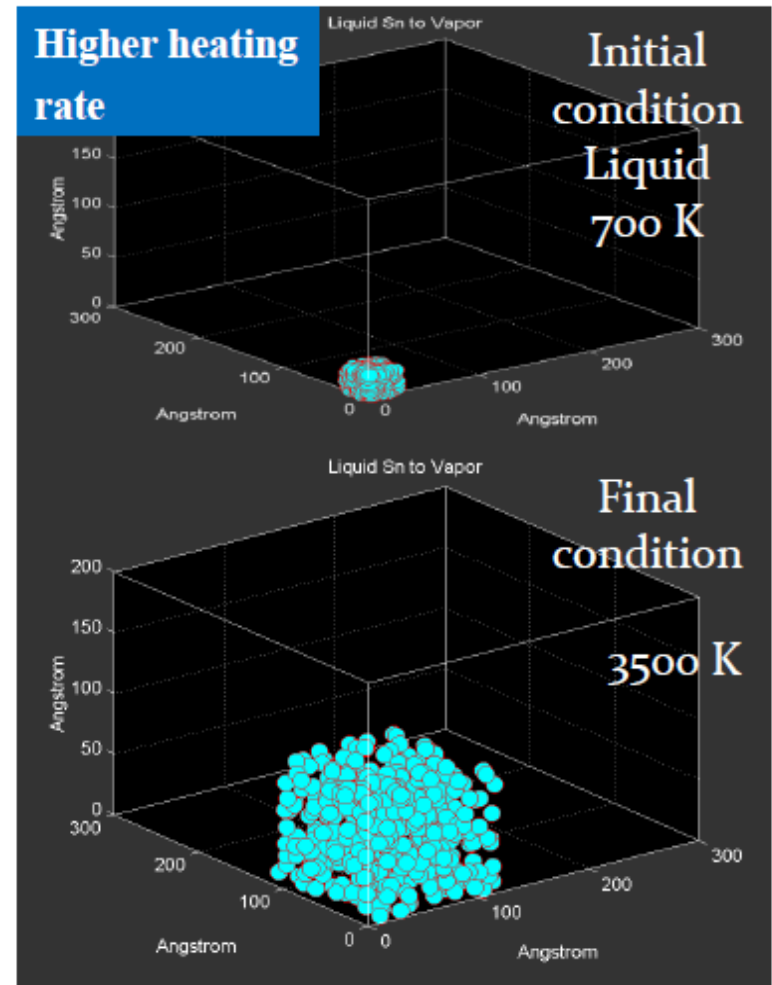
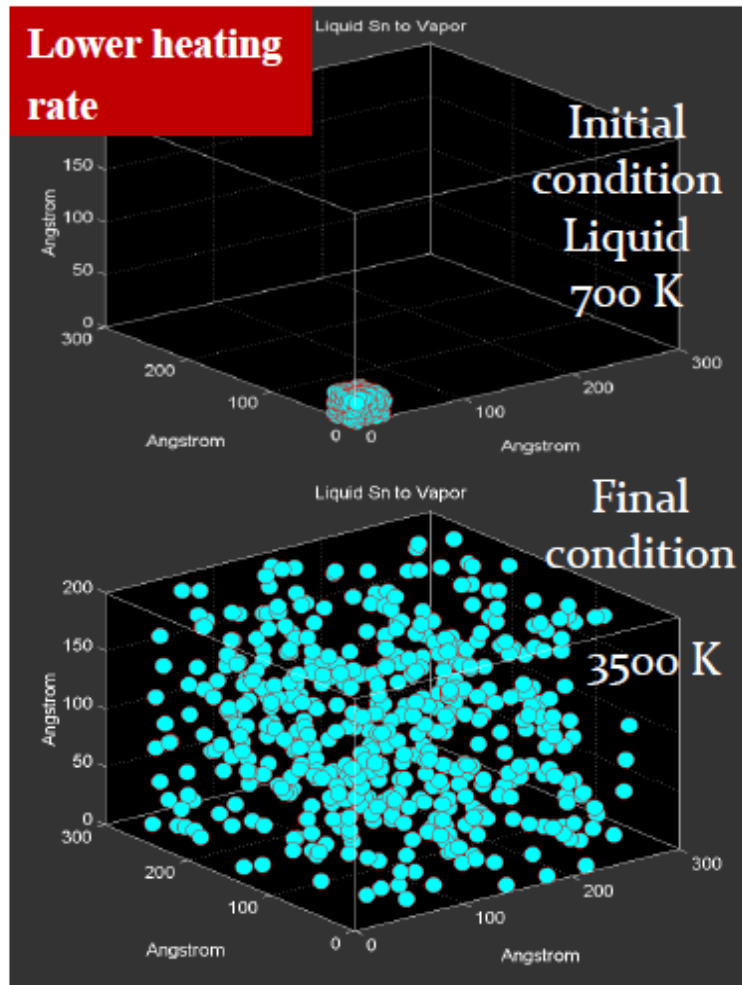
$$T = \frac{m}{3 N k_B} \sum_{i=1}^N \left( \sum_{\alpha=1}^3 (v_{i,\alpha} - \bar{v}_\alpha)^2 \right)$$

**P(fast heating) > P(slow heating)**

# Molecular dynamics simulation

## Boiling & Vaporization

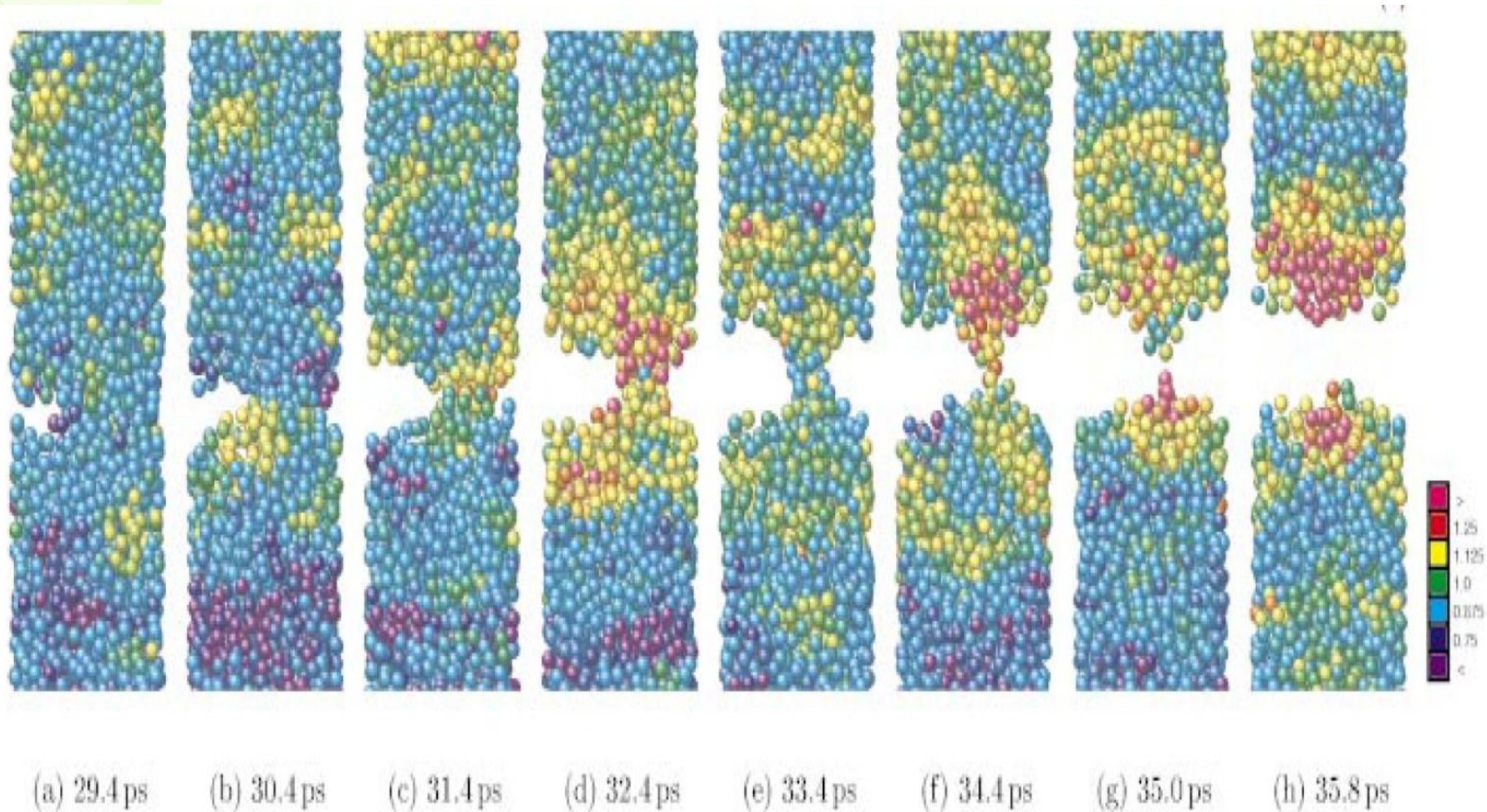
### Inertial confinement effect



**Thermal history changes the thermodynamic pathways.**

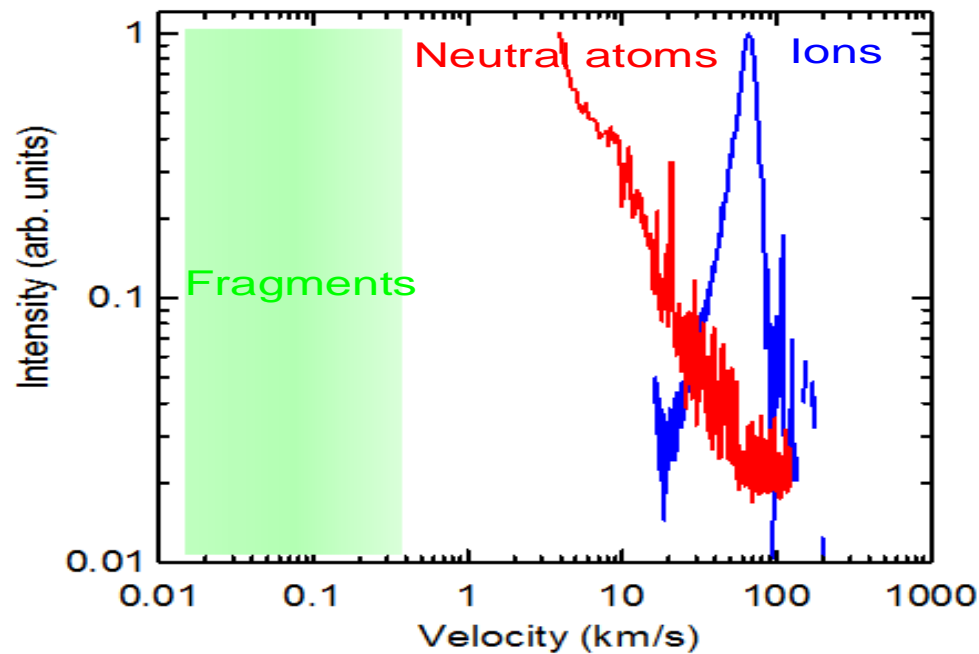


# Pressure dynamics from MD calculation



**Strong impulse continues less than 10ps due to plasma shield**

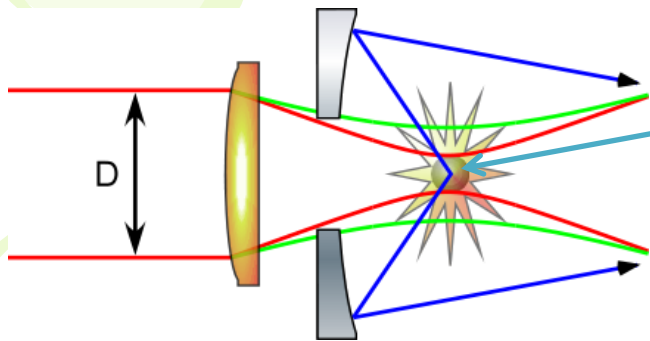
# Measured Speed ; ions, neutrals and fragments in pre-pulse; 100 $\mu$ m diameter Sn droplet, 10ns laser



**Pre-pulse laser is effective in ps pulse width  
as impulse for droplet spallation**



# Focusing Property of Pre-pulse Laser



Target size:  $\phi 10\mu\text{m}$

Target size:  $10\mu\text{m}$   
Focal length of lens:  $f=100\text{mm}$

•  $D=20\text{mm}$

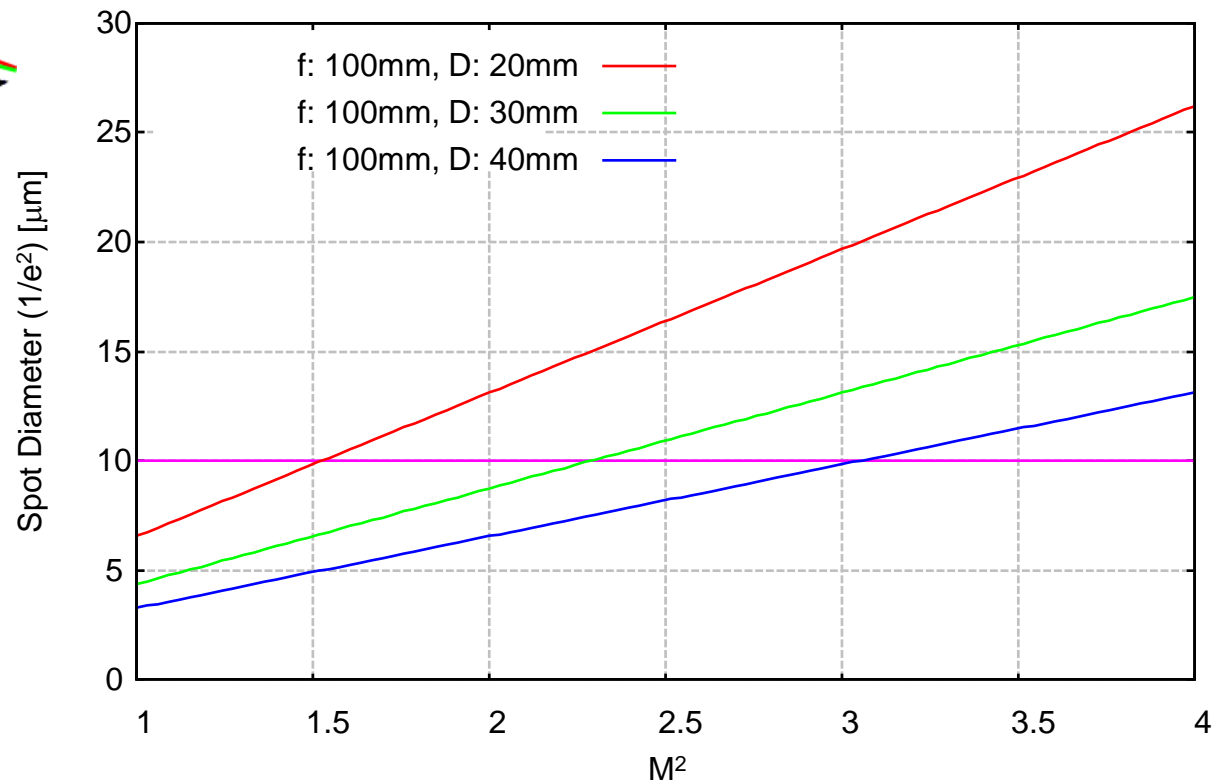
$M^2 < 1.5$

•  $D=30\text{mm}$

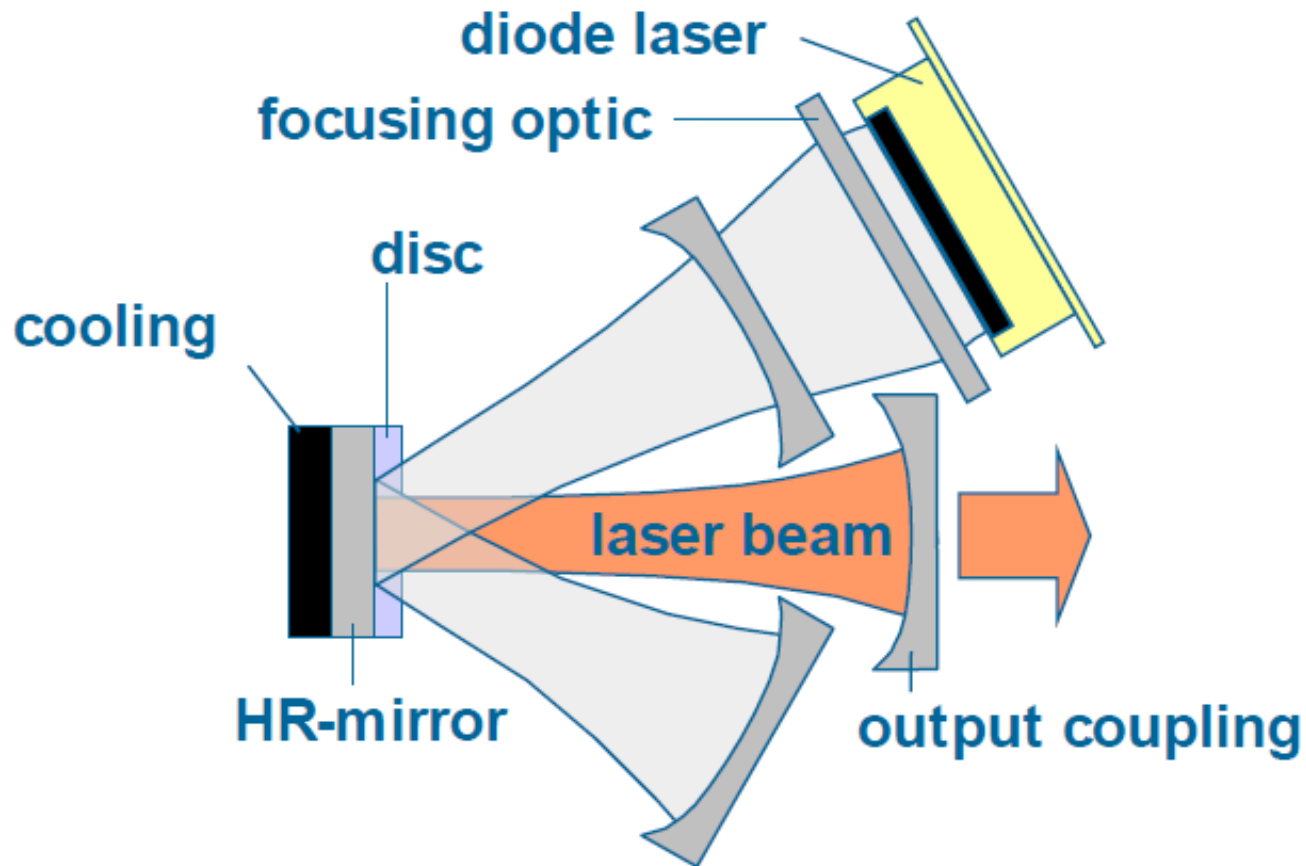
$M^2 < 2.3$

•  $D=40\text{mm}$

$M^2 < 3$

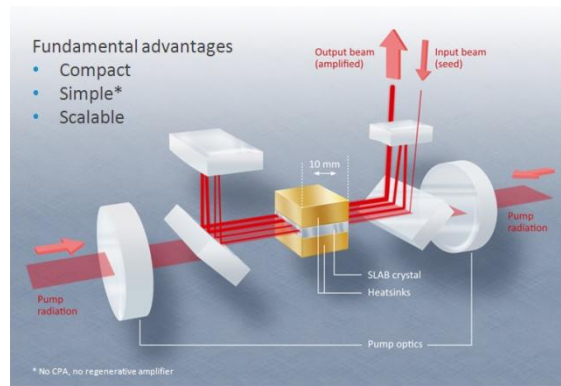
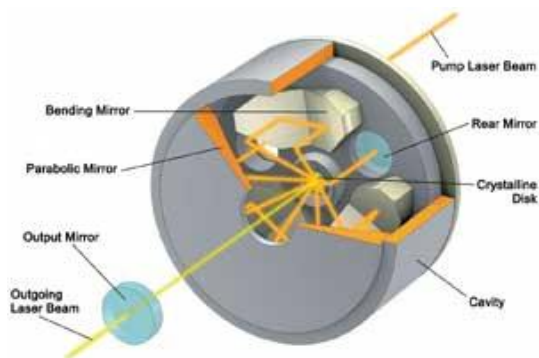


# Thin disc laser configuration



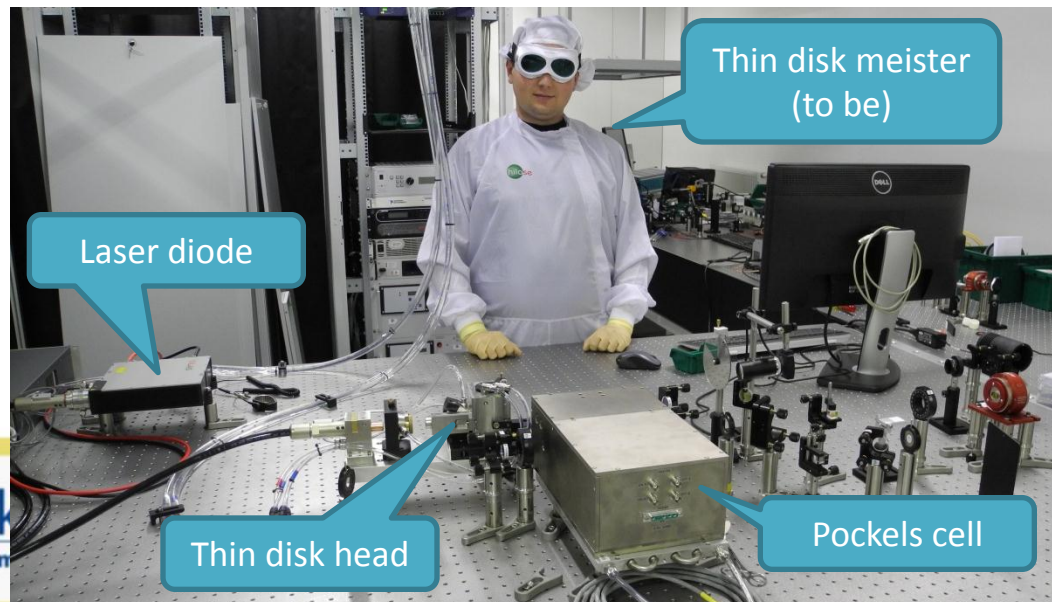
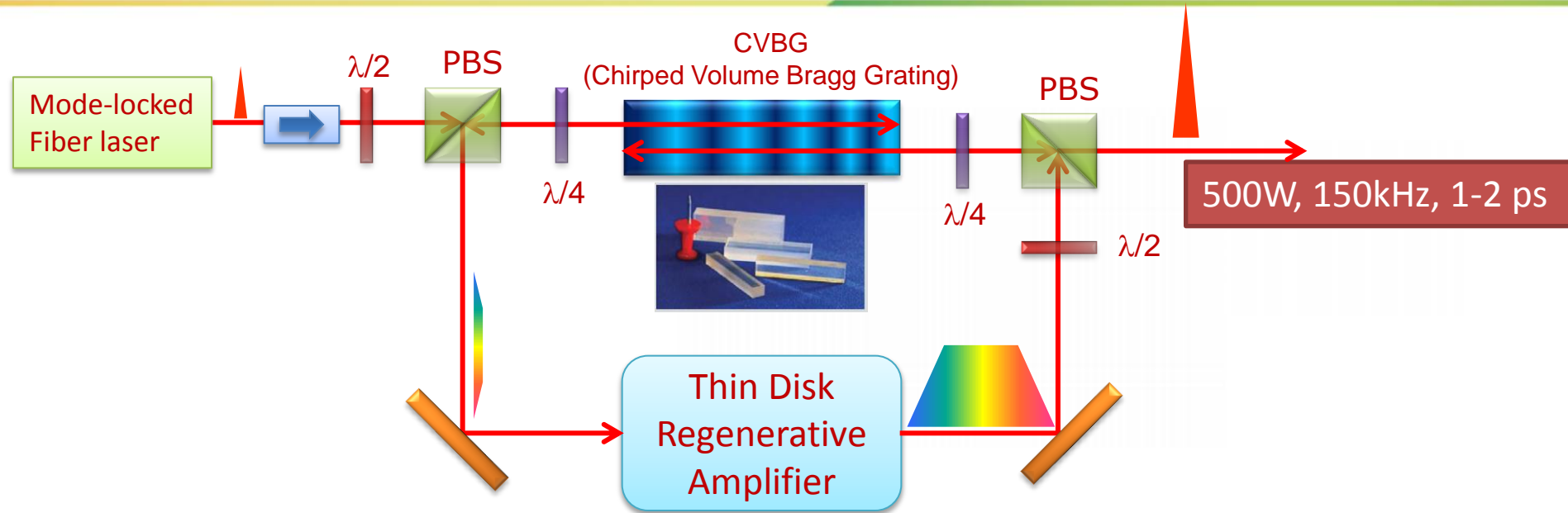
# High Energy Picosecond Pulse Sources

	Dual Thin disk Regen. (MPQ, 2012)	Single Thin disk Regen.[1] (MPQ, 2009)	Single Thin disk Regen.[2] (MBI, 2011)	Single Thin disk Multi-pass[3] (MBI, 2012)	Single Thin disk Multi-pass[4] (DESY, 2012)	Innoslab[5] (DESY, 2011)	Innoslab[5] (DESY, 2011)
Repetition rate [Hz]	1,000,000	3,000	150	100	10 (100kHz burst)	12,500	100,000
Pulse energy [mJ]	0.23	25	305	548	3560 (80 pulses)	20	2
Average output [W]	230	75	45.8	54.8	35.6	250	200
Pump energy [J]	CW	0.1	3.8	6.0	16.1	CW	CW
Pump power [W]	600	280	562.5	600	161.2	600	600
O-O Efficiency [%]	38.3%	26.8%	8.1%	9.1%	22.1%	41.7%	33.3%

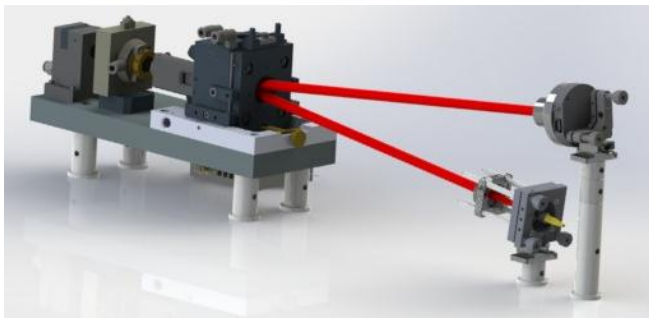


- [1] T. Metzger *et al.*, Opt. Lett. **34**, pp. 2123 (2009).
- [2] H. Stiel *et al.*, PTB Seminar EUV Metrology (2011).
- [3] R. Jung *et al.*, Disklaser Workshop (2012).
- [4] M. Schulz *et al.*, Opt. Express **20**, pp. 5038 (2012).
- [5] M. Schulz *et al.*, Opt. Lett. **36**, pp. 2456 (2011).

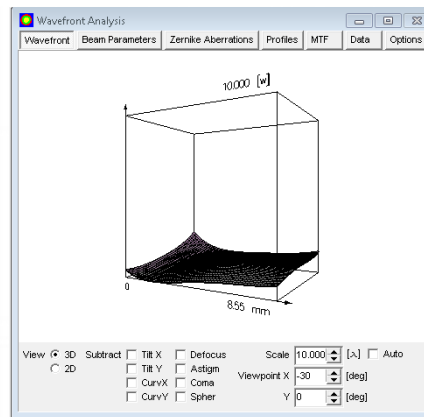
# Table-top High Power Laser Source in HiLASE



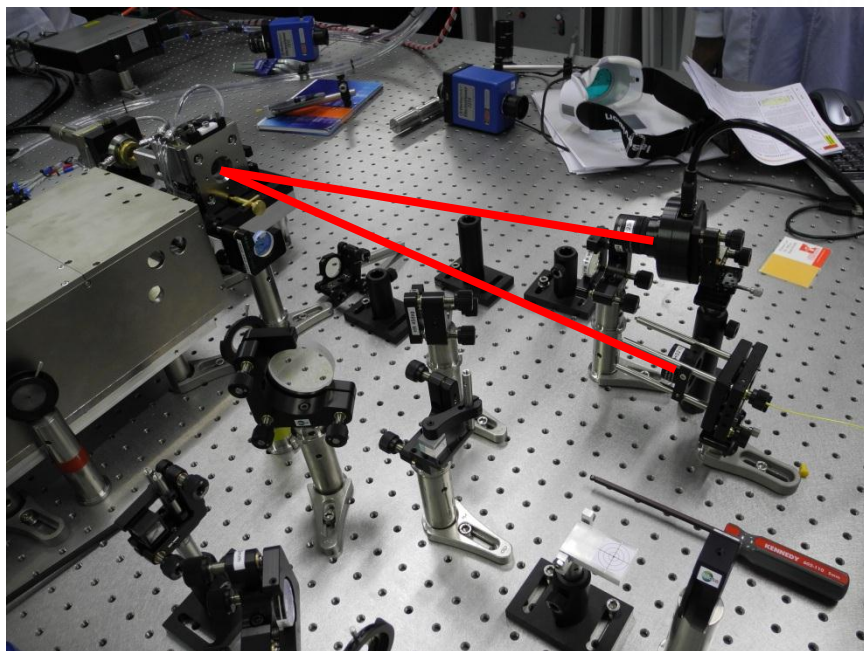
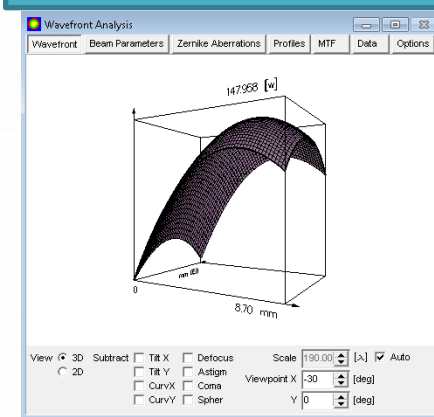
# In-situ Measurement of Thin Disk Deformation



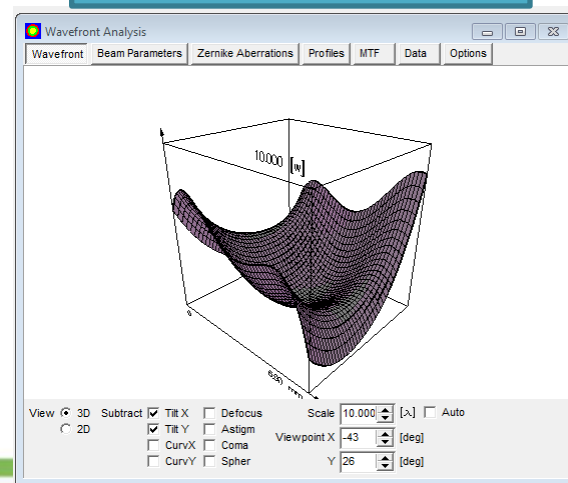
Wavefront from flat mirror



Wavefront from concave mirror (R=400mm)

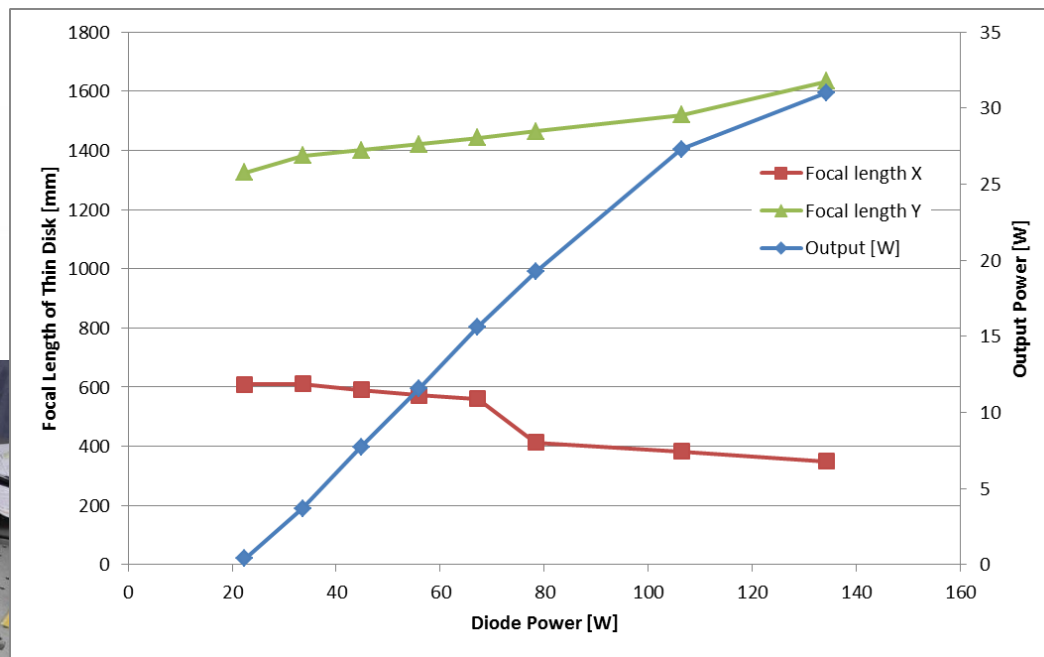
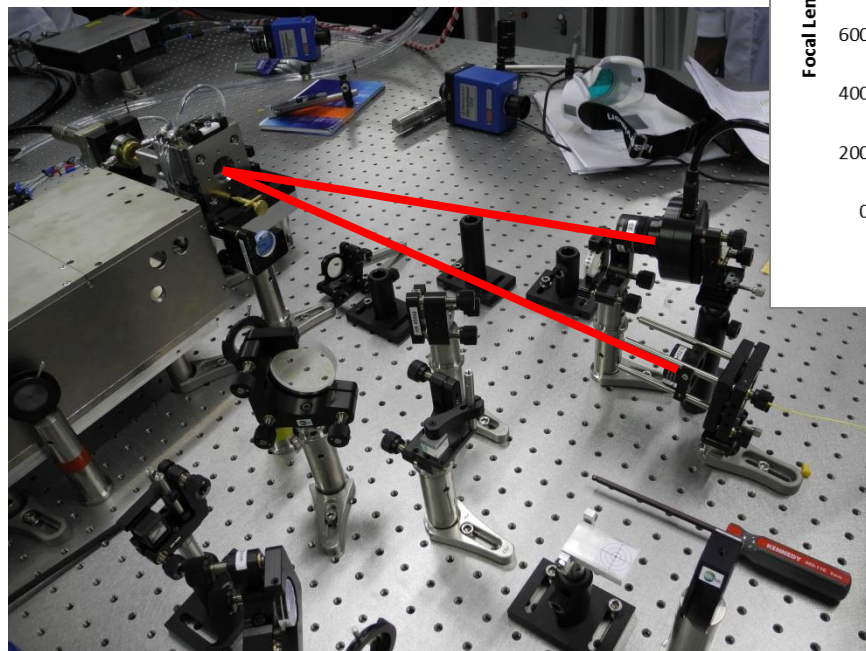


Wavefront from thin disk





# Preliminary Result of Thin Disk Deformation Measurement



# RP1 Group



P. Severova

Analysis by simulations  
Exploring improvements

Comparison with  
numerical model

T. Miura

Evaluation of thin disk  
deformation ,gain (ASE) etc.

Suggestions for  
improvement

M. Smrz

O. Novak

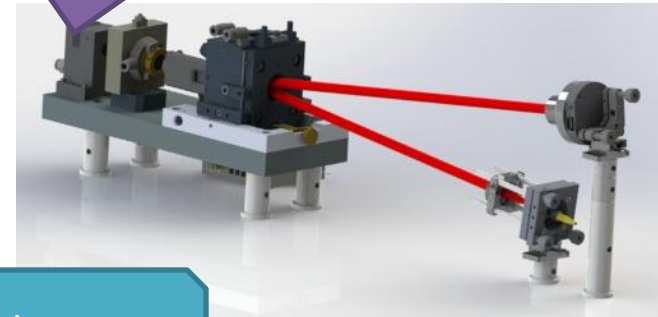
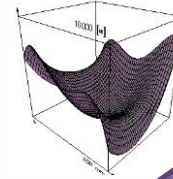
A. Endo  
(RP1 leader)



M. Chyla

High energy Thin disk  
Regenerative amplifier  
Ring amplifier

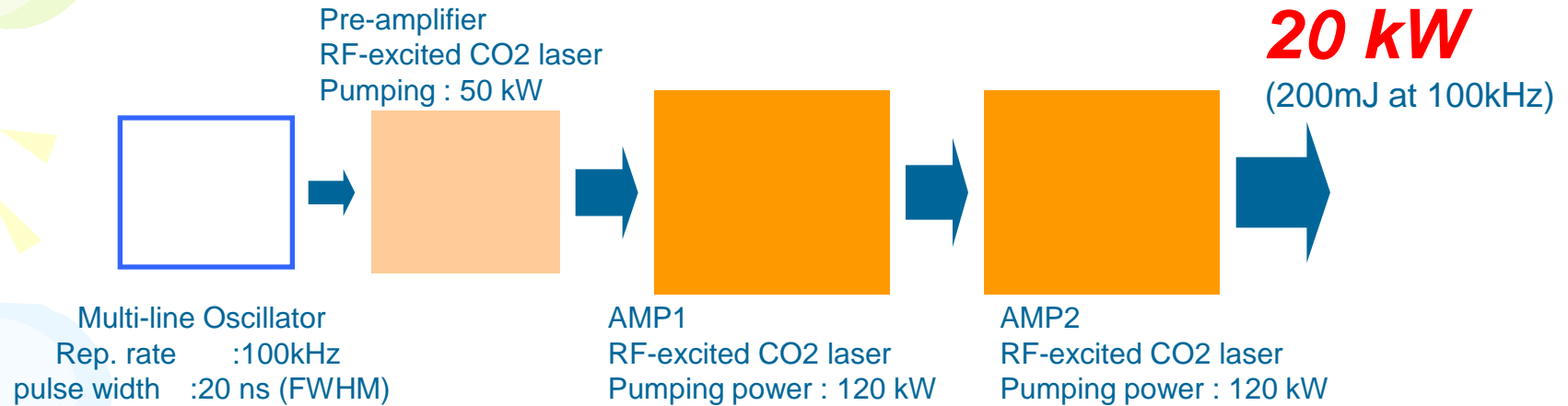
Real-time measurement



Applications (EUV BEUV HHG ...)



# Multi 10 kW Short Pulse CO<sub>2</sub> laser MOPA system



One beam, 25 kW is a reasonable estimate

## ➤ Power Limitation

- **Wavefront distortion**

- ⇒ Thermal distortion of windows

- **Filling Factor**

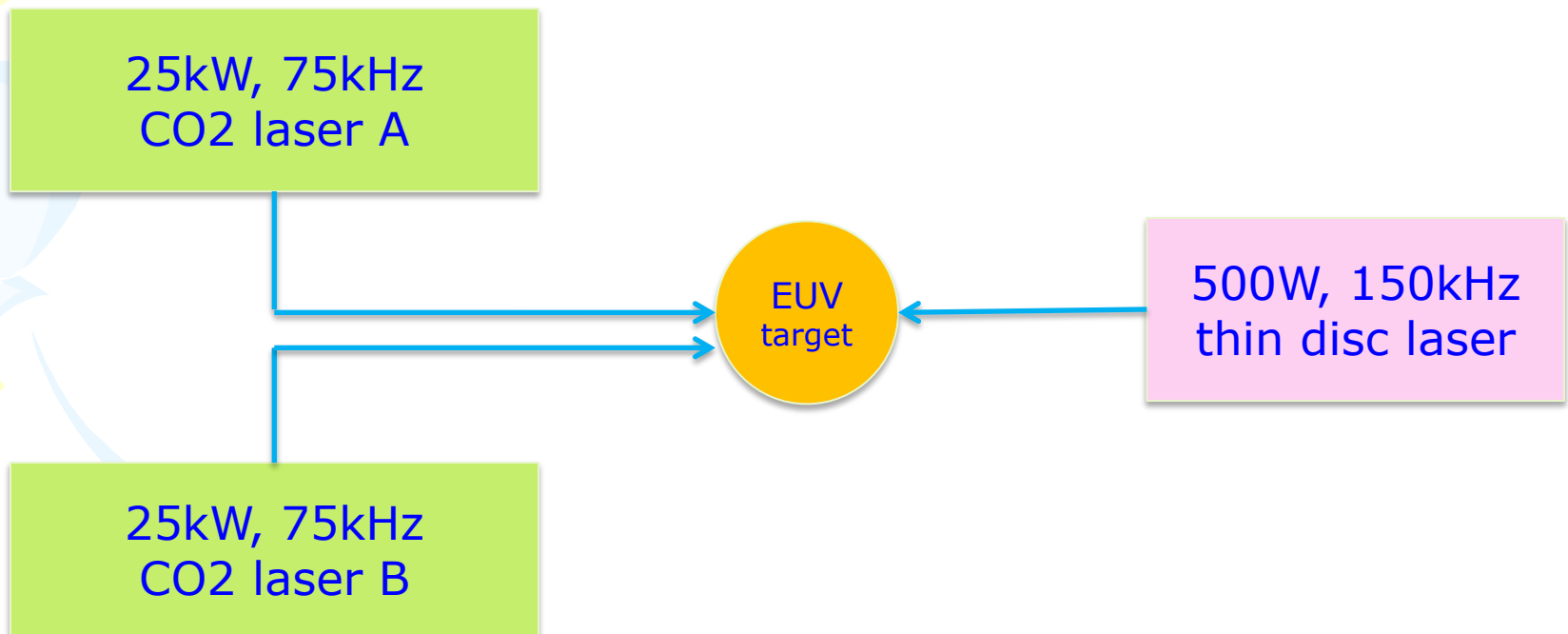
- ⇒ Laser beam diffraction ; beam delivery design

- **Stage isolation**

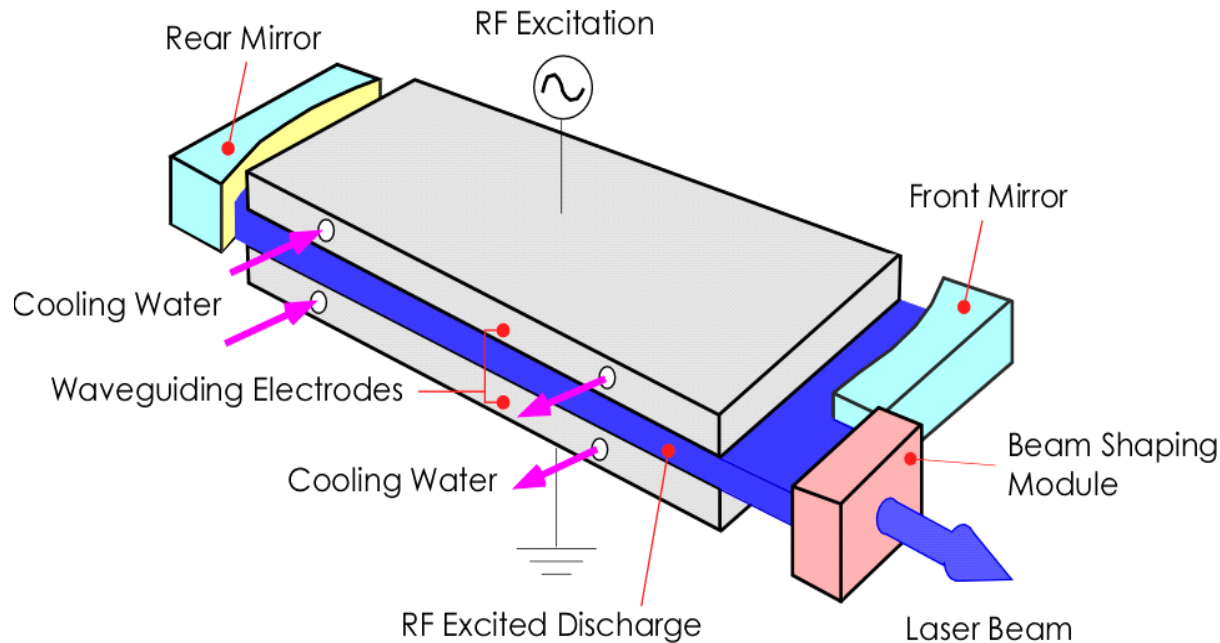
- ⇒ Loss due to amplified spontaneous emission



# Configuration of 150kHz, 1kW EUV source



# Diffusion-cooled slab CO<sub>2</sub> laser as a pre-amplifier

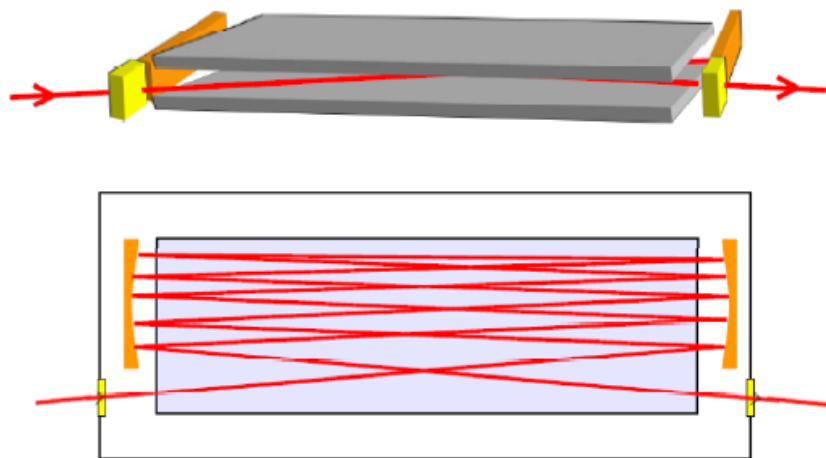


- **high efficiency energy extraction**
- **high beam quality**
- **excellent thermal stability**
- **no gas flow**
- **compactness**
- **low noise**
- **not expensive maintenance**

# Multi-pass amplifier arrangement

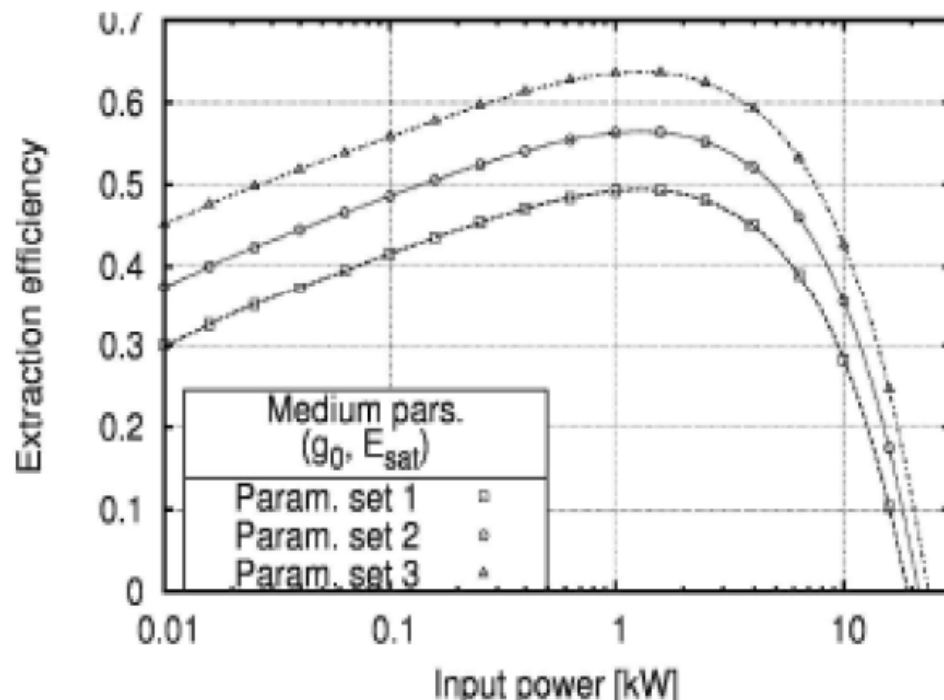
## ➤ Multi-pass amplifier

Slab-waveguide amplifier based on RF-discharge excited diffusion-cooled CO<sub>2</sub> lasers



## ➤ Extraction efficiency

Calculated performance of multi-pass pre-amplifier



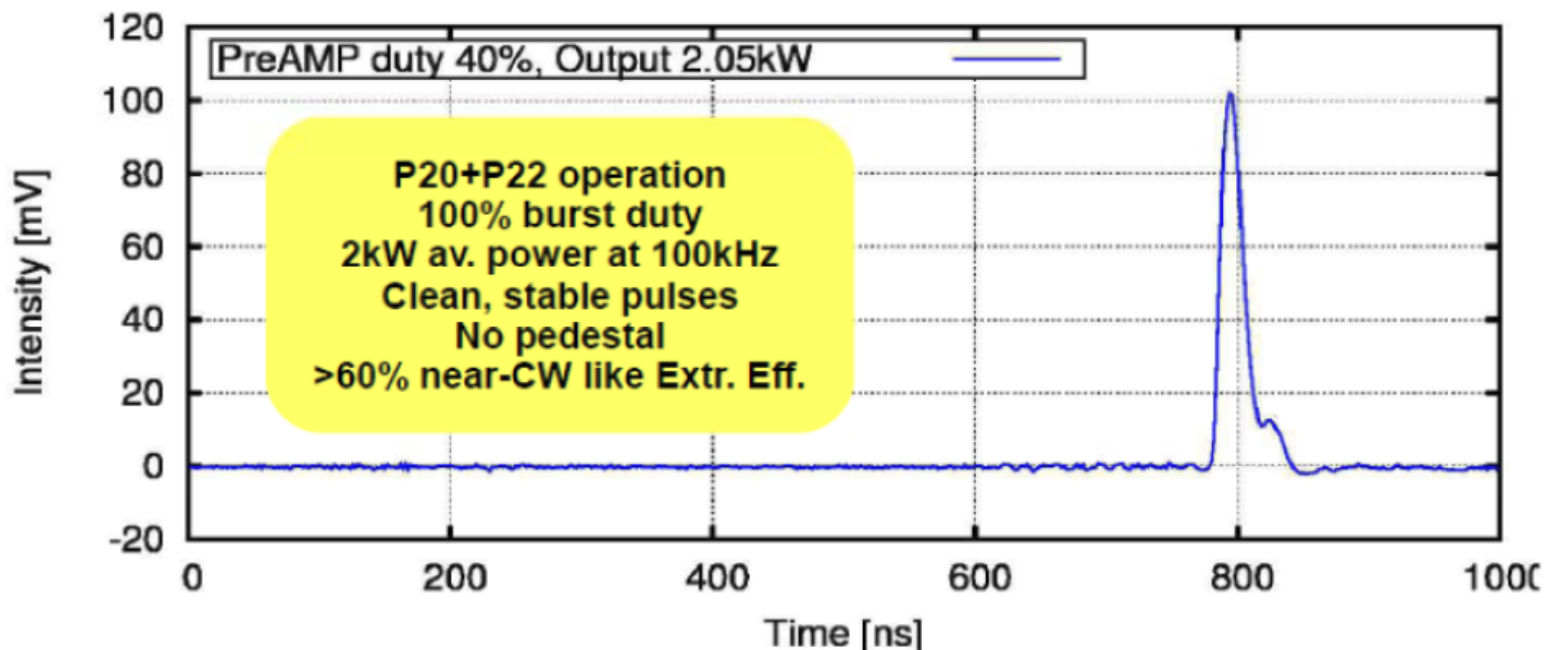
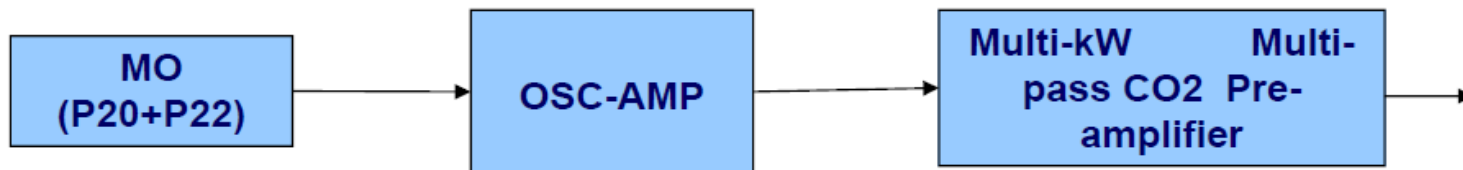
**Maximum extraction efficiency\* : 35-60%**

**Input for max Extraction Efficiency : 1-3kW**

\*As compared to CW power output at full RF duty

**KOMATSU**

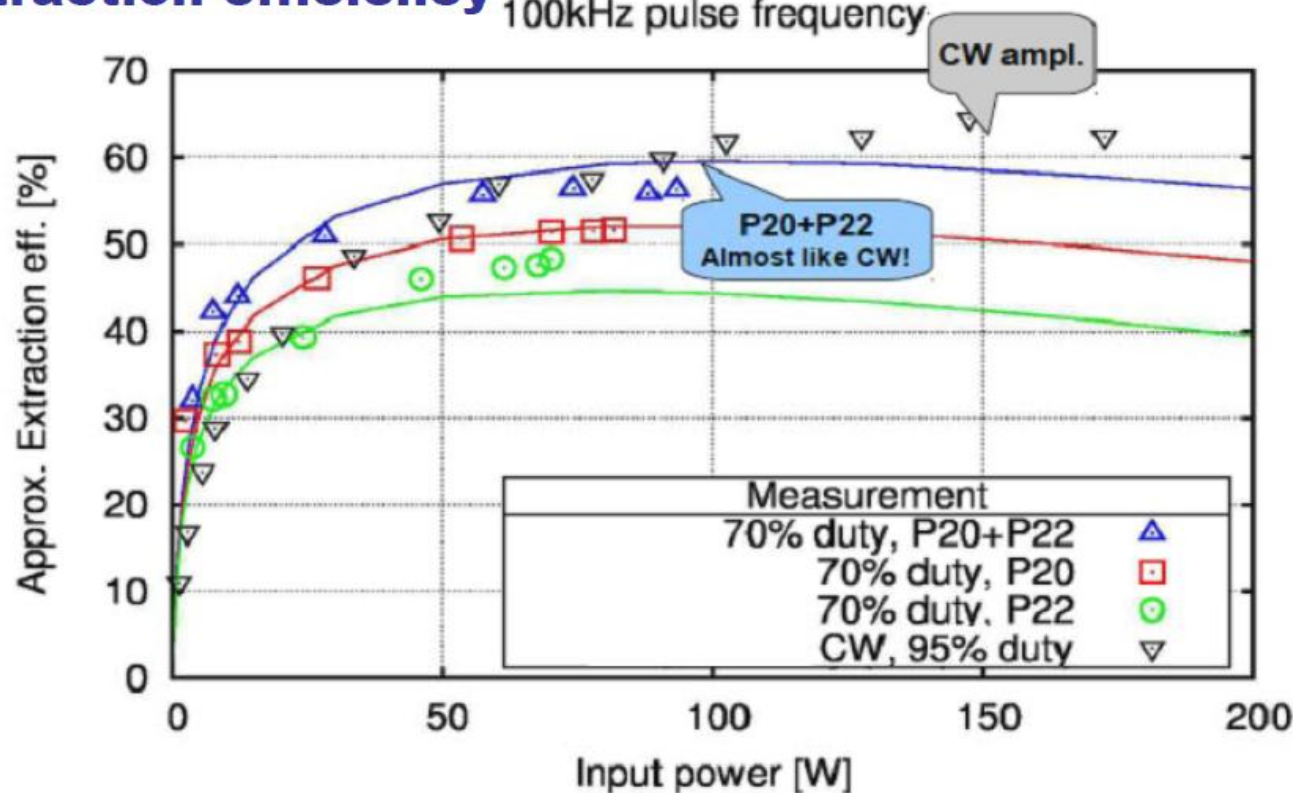
## Multi-line amplification results : Pre-AMP



***2kW output was achieved at near-CW extraction.***

## Multi-line amplification results : OSC-AMP

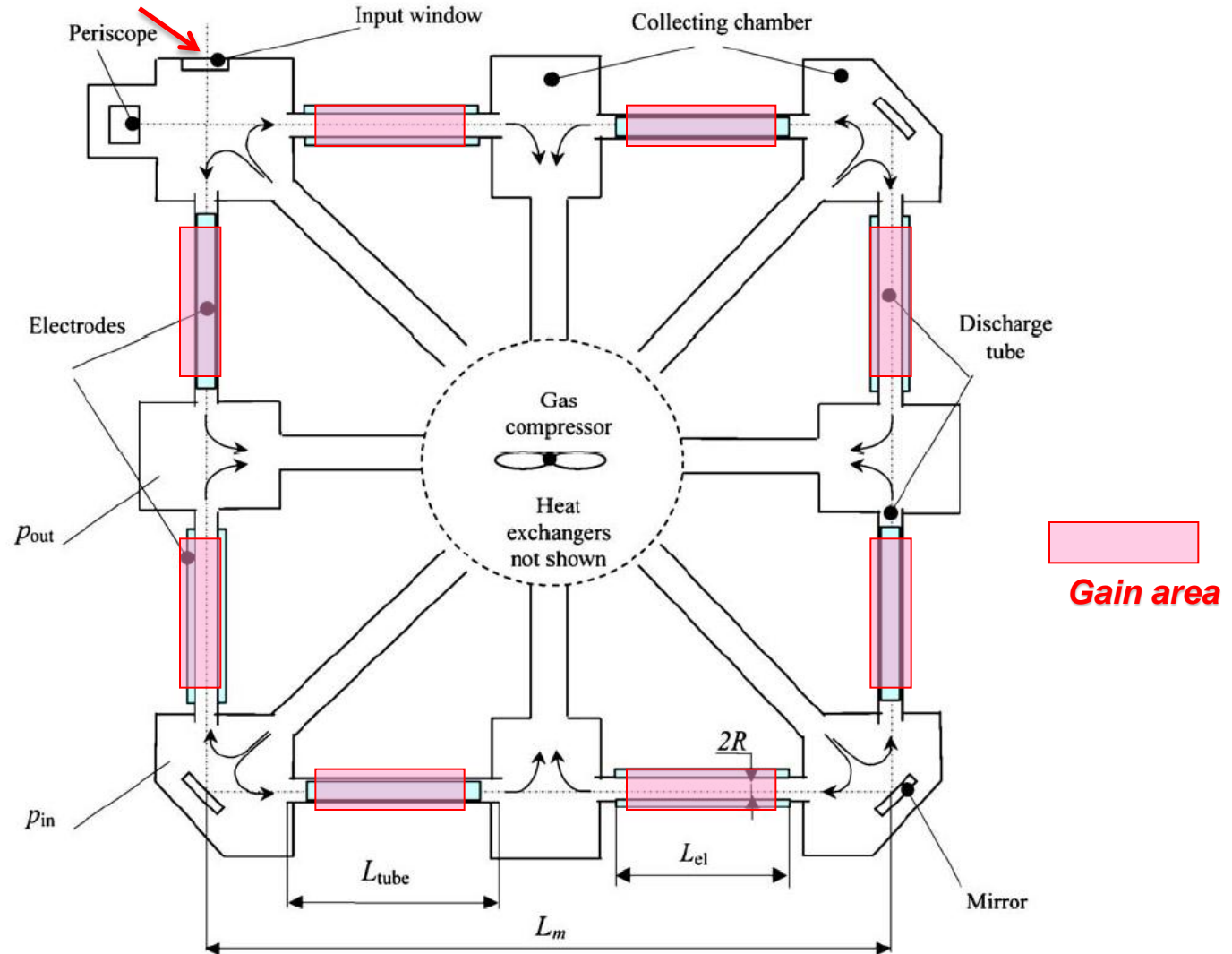
### ➤ Extraction efficiency 100kHz pulse frequency



**10% energy extraction improvement using 2 lines (P20+P22) as compared to single line (P20) was confirmed**

# Discharge tubes of main axial flow amplifiers

Output window



Two stage structure

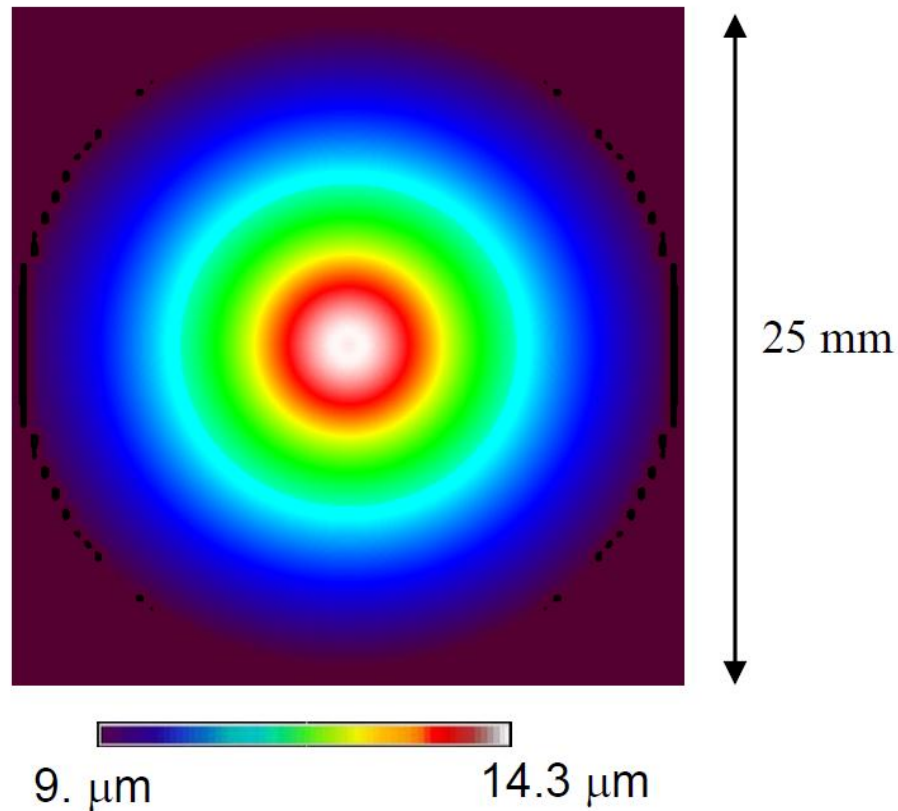


# OPD(optical path difference)

50kW/cm<sup>2</sup> with d=7mm

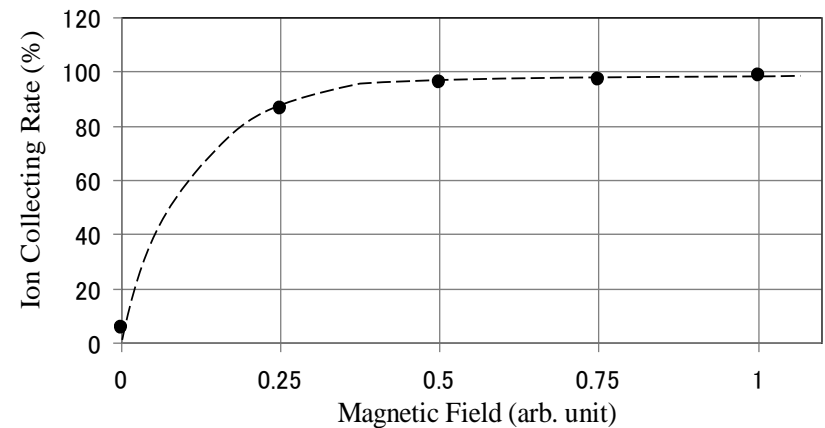
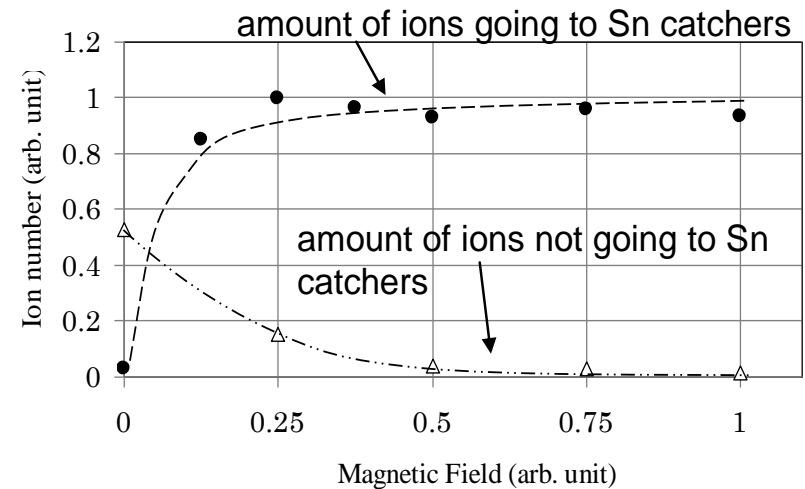
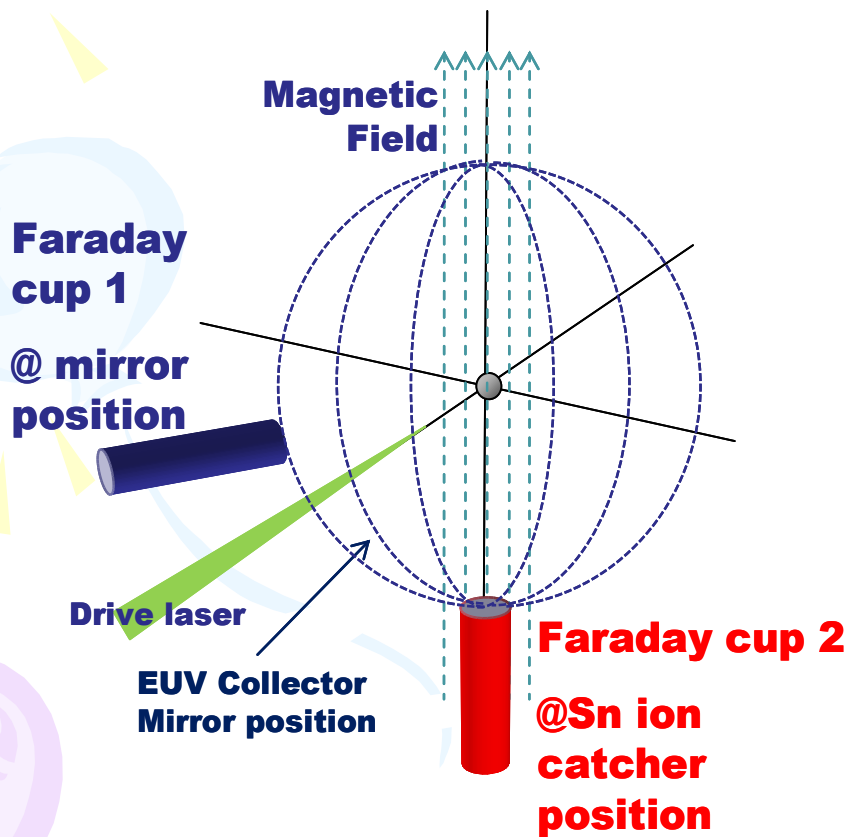
ZnSe (12.5mm thick)

Wavefront Deformation



# Sn vapor control for better EUV collection efficiency

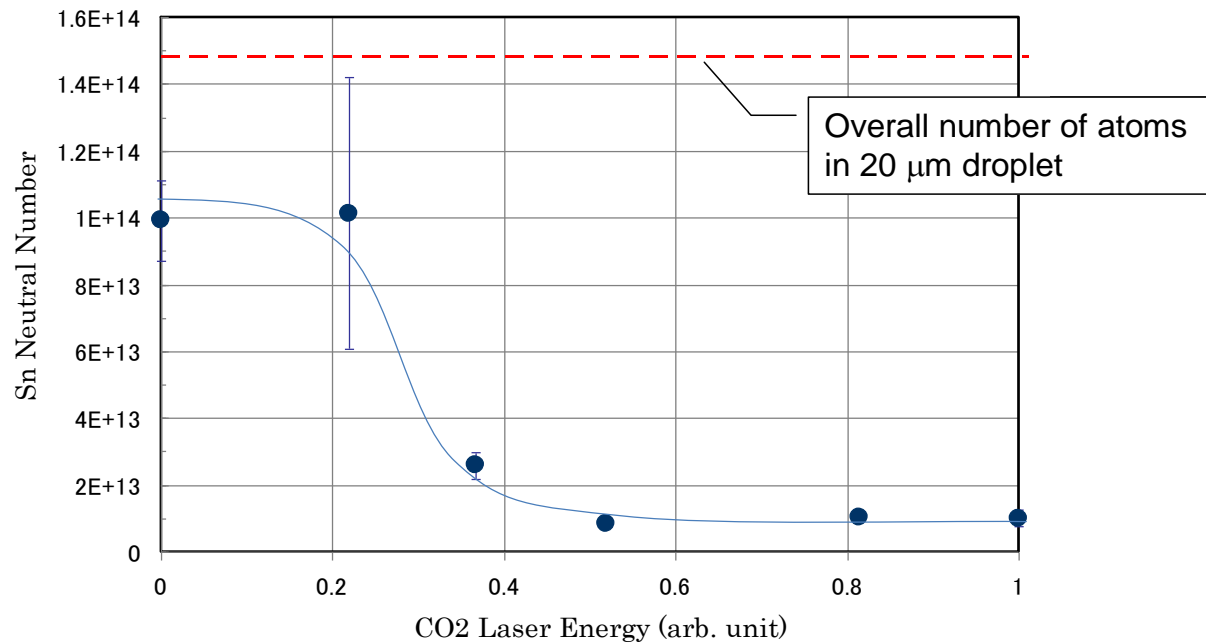
Ion and neutral particle drift in transport magnetic field



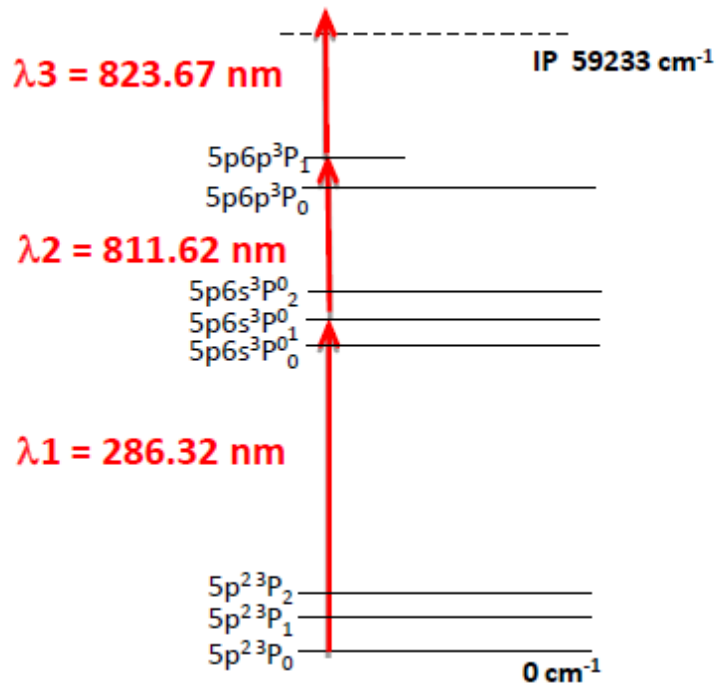


# Remaining neutrals

**>99% injected Sn atoms are collected by magnetic method. Additional ionization increases further recovery, and better EUV collection efficiency results.**



# Laser resonant ionization of Sn



$E_s = 0.19 \text{ mJ/cm}^2$

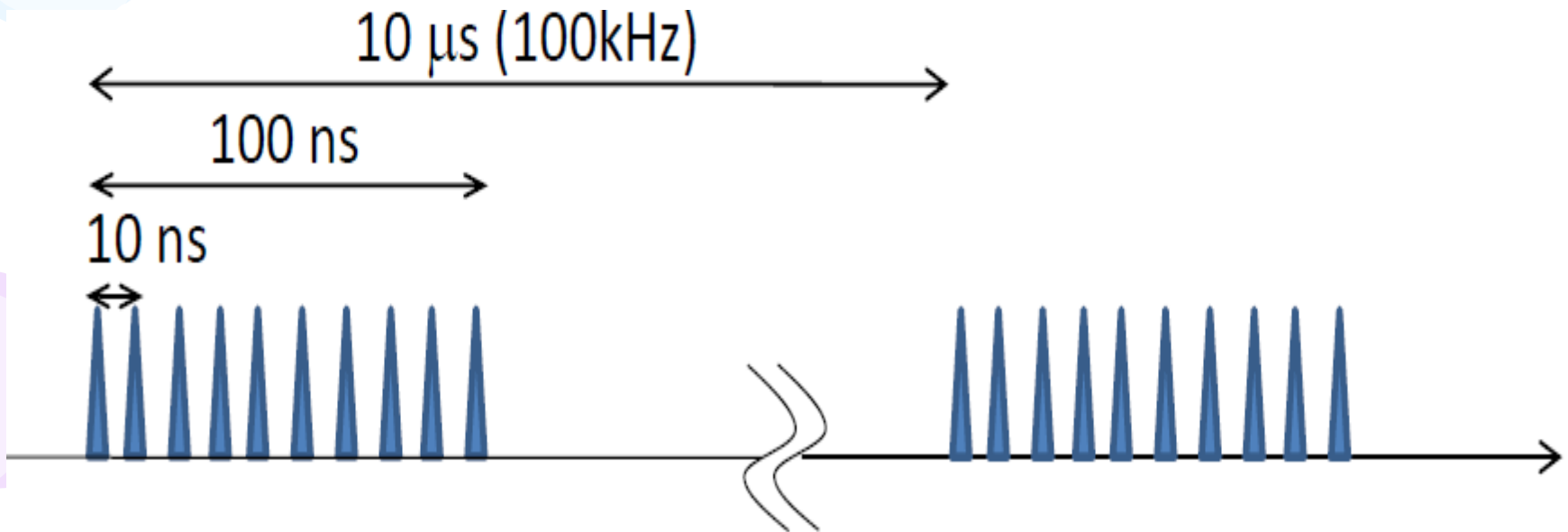
$E_s = 0.07 \text{ mJ/cm}^2$

$E_s = 1.38 \text{ mJ/cm}^2$

Energy diagram

Saturation fluence

# Laser resonant ionization of Sn neutral atoms in partially ionized, cross correlated plasma (complex plasma)





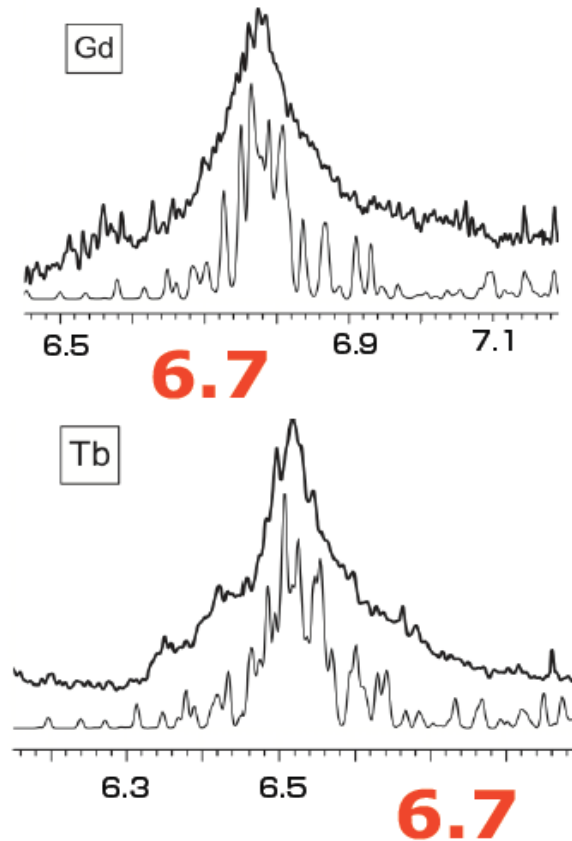
# Intermediate Conclusion

**LPP HVM architecture is scalable over 1kW**

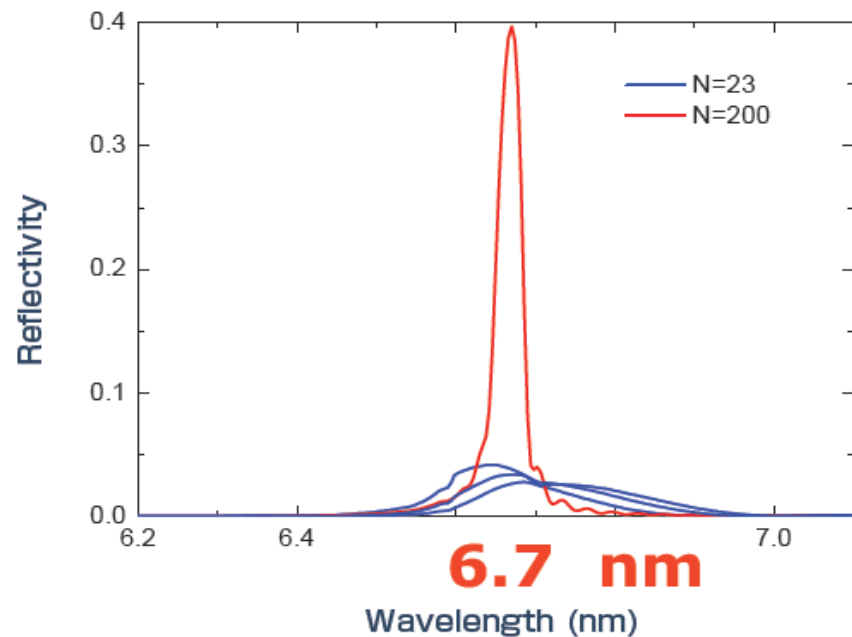
- Speedup of 10 $\mu$ m diameter Tin droplet to 150m/s
- Dual CO<sub>2</sub> laser modules are operated for 150kHz
- Sn Cluster formation by picosecond solid state laser
- Laser resonant ionization of neutrals

# Scaling of HVM source technology to BEUV wavelength operation

## 6.7 nm: Gd, Tb plasmas



## Mo/B<sub>4</sub>C mirror



 **Fraunhofer**  
IOF

S. S. Churilov *et al.*, Phys. Scr. **80**, 045303 (2009).



# Effective conversion efficiency

Drive laser	Solid state laser	CO2 laser
Sn (/2%b.w.)	1.5%	4.5%
Gd (/0.6%b.w.)	0.5%	1.5%*

\* Estimation from recent experiments ( S11, T.Higashiguchi ; Plasma-based UTA emission in BEUV & water window spectral regions)



# Operational parameters BEUV kW HVM source (1)

<b>EUV IF power</b>	<b>1kW (6.xnm)</b>
CO2 laser power	160kW
Conversion efficiency	1.5%/0/6%b.w. *
Collection efficiency	40%
Mirror reflectivity	70% **

\* very probable

\*\* expected in this decade

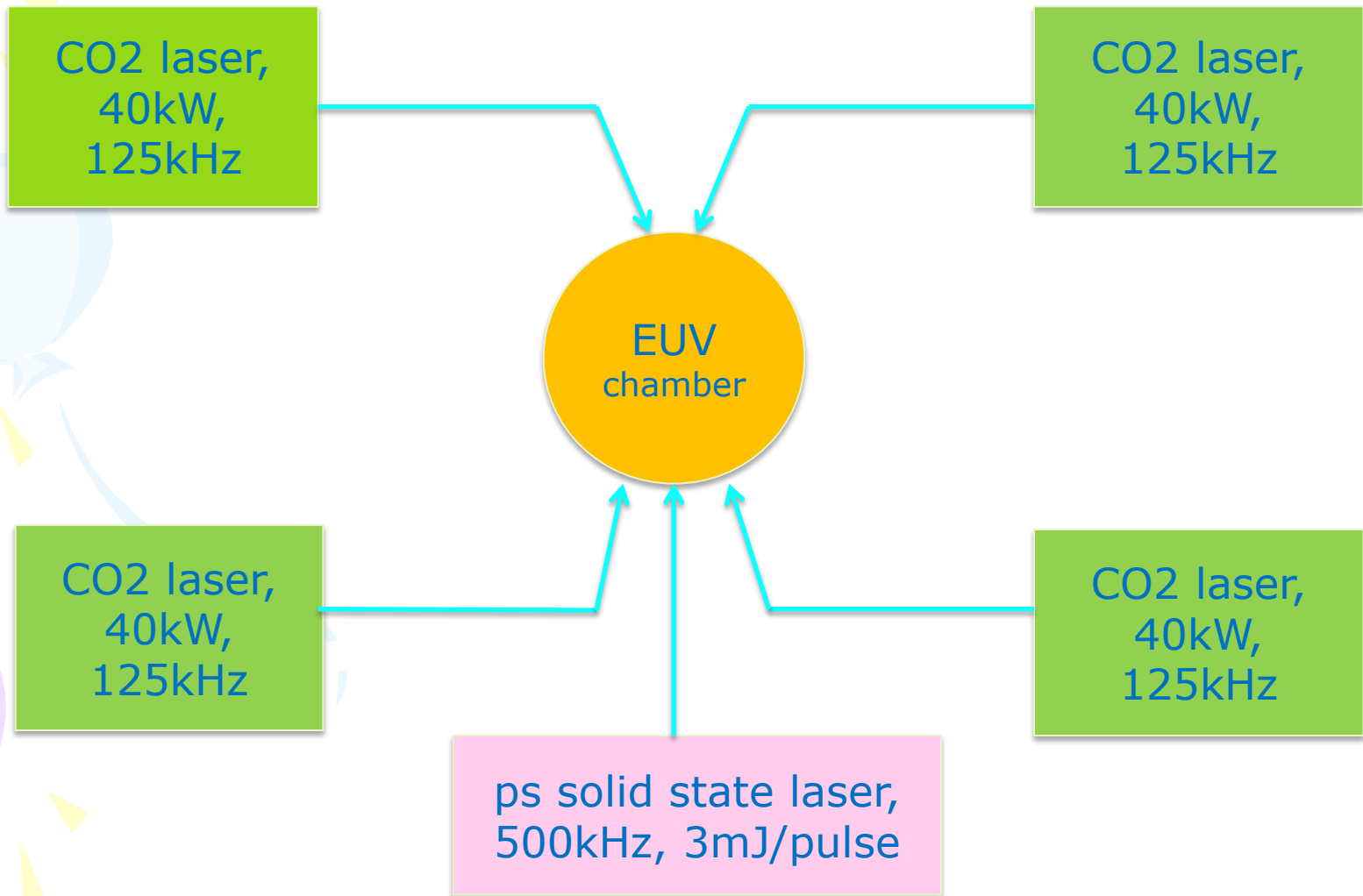
# Operational parameters BEUV kW HVM source(2)

Repetition rate	500kHz	Subjects
droplet	10μm Gd liquid	Molten temperature * 1312°C
irradiation	double pulse	assume same spallation as Sn *
droplet interval	1mm	assume same expansion as Sn*
droplet speed	500m/s	< MV static acceleration
fuel recovery and reuse	full ionization and magnetic guide	Rare earth efficient laser ionization

\* Gd droplet generator development desirable



# Configuration of 500kHz, 1kW BEUV source





# Cocclusion

LPP HVM architecture is scalable over 1kW

BEUV HVM source needs x 3 drive laser power due to narrower bandwidth of C1 mirror

Comparison with non plasma approach meaningful